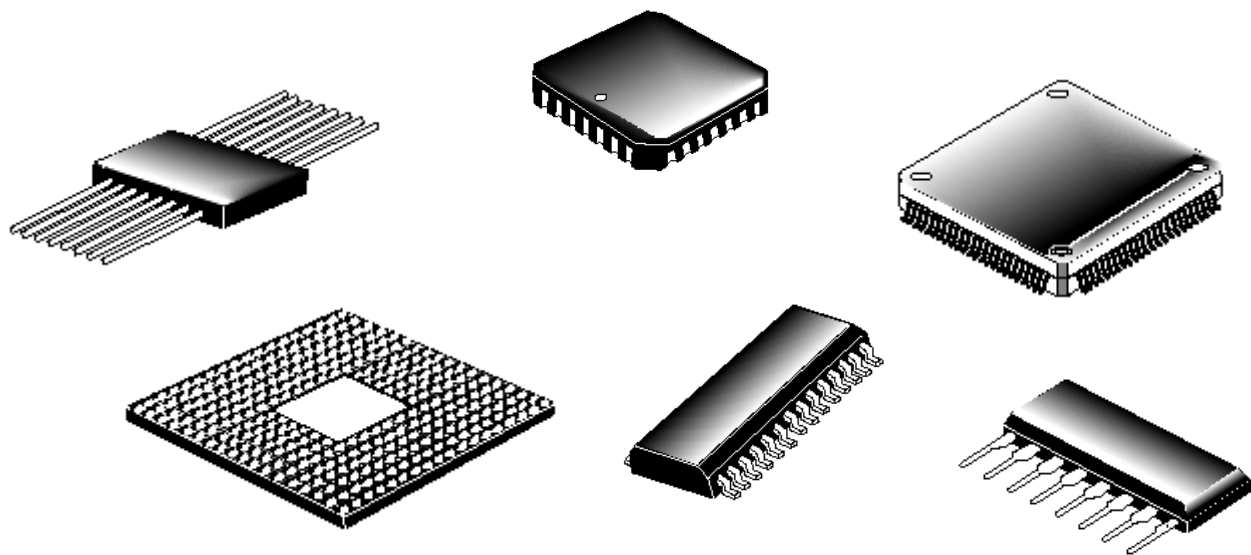


# **FAILURE MECHANISM BASED STRESS TEST QUALIFICATION FOR INTEGRATED CIRCUITS**



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## Revision Summary

This informative section briefly describes the changes made in the AEC-Q100 Rev-H document, compared to previous document version, AEC-Q100 Rev-G (May 14, 2007). Punctuation and text improvements are not included in this summary.

- Section 1.2.1 – Automotive Reference Documents: Added reference to AEC-Q005 Pb-Free Requirements
- NEW Section 1.2.4 – Decommissioned Reference Documents: Added new section providing guidance on elimination of AEC-Q100-003 Machine Model ESD (removed due to industry test obsolescence) and Q100-006 Electrothermally Induced Gate Leakage (removed due to lack of industry need as a qualification test)
- Section 1.3.1 – AEC Q100 Qualification: Added recommendation that passing ESD voltage level be specified in supplier datasheet with footnote on any pin exceptions
- NEW Section 1.3.2 – AEC Certification: Added new definition clarifying that AEC-Q100 “certification” does not exist, suppliers perform qualification testing according to AEC standards
- Section 1.3.4 – Definition of Part Operating Temperature Grade: Added new Table 1 defining part operating temperature grades and guidance on use of temperature (e.g., endpoint, junction) during tests; eliminated Grade 4 (0°C to +70°C) entry
- NEW Section 1.3.5 – Capability Measure, Cpk: Added new definition and reference to AEC-Q003 Characterization document
- Section 2.2 – Precedence of Requirements: Added clarification to Purchase Order and Device Specification entries
- Section 2.3.1 – Definition of Generic Data: Moved existing Table 1, Part Qualification/Requalification Lot Requirements, and portion of section text to Appendix 1 – Definition of a Product Qualification Family
- Section 2.3.2 – Time Limit for Acceptance of Generic Data: Added text on use of diagram in Figure 1
- Section 2.4.1 – Lot Requirements: Added statement that deviation from Table 2 requires technical explanation
- Section 2.5 – Definition of Test Failure After Stressing: Added statement on EOS
- Section 3.1.1 – Qualification of A New Device Manufactured in A Currently Qualified Family: Deleted this entire section, subject is covered in Appendix 1.
- Section 3.2.3 – Criteria for Passing Requalification: Modified text to provide better guidance on AEC-Q100 requalification
- NEW Section 3.3 – Qualification of A Pb-Free Device: Added new section with requirements for Pb-Free devices and references to AEC-Q005 Pb-Free Requirements document
- Figure 2 – Qualification Test Flow:
  - Test Group A: Removed statement of PC before PTC
  - Test Group B: Corrected test temperature order for post-HTOL testing to Room, Cold, & Hot
  - Test Group E: Removed reference to MM ESD and GL tests
- Table 2 – Qualification Test Methods:
  - Test A3 – Autoclave or Unbiased HAST or Temperature Humidity (without Bias): Added TH reference to Additional Requirements column
  - Test A4 – Temperature Cycling: Revised low-end temperature and minimum duration; added legacy test temperature note; eliminated Grade 4 entry
  - Test A6 – High Temperature Storage Life: Added reference to Ta (ambient temperature)
  - Test A7 – High Temperature Operating Life: Removed 408 hour test duration option; added notes regarding use of Ta (ambient temperature) and Tj (junction temperature)
  - Test C1 – Wire Bond Shear: Removed Ppk requirement; modified Cpk accept criteria to Cpk>1.67; added reference to AEC-Q003
  - Test C2 – Wire Bond Pull: Removed Ppk requirement; modified Cpk accept criteria to Cpk>1.67; added reference to AEC-Q003
  - Test C3 – Solderability: Added reference to J-STD-002D and statement on use of dry bake

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**Revision Summary (continued)**

- Table 2 – Qualification Test Methods (continued):
  - Test C4 – Physical Dimension: Removed Ppk requirement; modified Cpk accept criteria to  $Cpk > 1.67$ ; added reference to AEC-Q003
  - Test C5 – Solder Ball Shear: Removed Ppk requirement; modified Cpk accept criteria to  $Cpk > 1.67$ ; added reference to AEC-Q003
  - Test E2 – Electrostatic Discharge Human Body Model/Machine Model: Eliminated Machine Model (MM) ESD entry; added reference to Section 1.3.1
  - Test E3 – Electrostatic Discharge Charged Device Model: Added reference to Section 1.3.1
  - Test E5 – Electrical Distribution: Added  $Cpk > 1.67$  accept criteria and reference to AEC-Q003
  - Eliminated Test E8 – Electrothermally Induced Gate Leakage entry
  - NEW Test E12 – Lead (Pb) Free: Added new test entry
  - Test F1 – Part Average Testing: Modified Additional Requirements providing guidance on sample sizes and accept criteria
  - Test F2 – Statistical Bin/Yield Analysis: Modified Additional Requirements providing guidance on sample sizes and accept criteria
  - Test G1 – Mechanical Shock: Modified sample size/lot and number of lots
  - Test G2 – Variable Frequency Vibration: Modified sample size/lot and number of lots
  - Test G3 – Constant Acceleration: Modified sample size/lot and number of lots
  - Test G4 – Gross/Fine Leak: Modified sample size/lot and number of lots
  - Test G8 – Internal Water Vapor: Modified sample size/lot
  - Table 2 Legend: Added Note L reference for Pb-Free devices
- Table 3 – Process Change Qualification Guidelines for the Selection of Tests: Removed MM (Machine Model) ESD and GL (Gate Leakage) entries; added LF (Lead Free) entry
- Appendix 1 – Definition of a Product Qualification Family: Complete revision
  - NEW Section A1.1 – Product: Added new section and text
  - NEW Section A1.4 – Qualification/Requalification Lot Requirements: Relocated original AEC-Q100 Rev G Table 1 to Appendix 1 and renumbered as Table A1.1
  - Revised Table A1.1 – Part Qualification/Requalification Lot Requirements: Deleted row titled “A new part that has some applicable generic data”; added NEW entry where “The part to be qualified is slightly more complex”
  - NEW Table A1.2 – Examples for Generic Data Use: Added new Table and content
- Appendix Template 4A – AEC-Q100 Qualification Test Plan:
  - Test C3, SD - Solderability: Added reference to J-STD-002D and requirement of steam aging
  - Test E2, HBM/MM – ESD Human Body/machine Model: Eliminated MM entry
  - Test E8, GL – Electrothermally Induced Gate Leakage: Eliminated GL entry
  - Tests G1-G4, MECH – Hermetic Package Tests: Modified sample size and lot requirements
- Appendix Template 4B – AEC-Q100 Generic Data:
  - Test C3, SD: Added reference to J-STD-002D and requirement of steam aging
  - Test E2, HBM/MM: Eliminated MM entry
  - Test E8, GL: Eliminated GL entry
  - Test G1, MS: Modified sample size and lot requirements
  - Test G2, VFV: Modified sample size and lot requirements
  - Test G3, CA: Modified sample size and lot requirements
  - Test G4, GFL: Modified sample size and lot requirements
  - Complete revision of Generic Data Part Attributes Section
- NEW Appendix 7 – Guideline on Relationship of Robustness Validation to AEC-Q100: Added NEW Section and text, including NEW Figures A7.1 & A7.2 and NEW Table A7.1

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**FAILURE MECHANISM BASED STRESS TEST QUALIFICATION  
FOR PACKAGED INTEGRATED CIRCUITS**

*Text enhancements and differences made since the last revision of this document are shown as underlined areas. Several figures and tables have also been revised, but changes to these areas have not been underlined.*

**Unless otherwise stated herein, the date of implementation of this standard for new qualifications and re-qualifications is as of the publish date above.**

**1. SCOPE**

This document contains a set of failure mechanism based stress tests and defines the minimum stress test driven qualification requirements and references test conditions for qualification of integrated circuits (ICs). These tests are capable of stimulating and precipitating semiconductor device and package failures. The objective is to precipitate failures in an accelerated manner compared to use conditions. This set of tests should not be used indiscriminately. Each qualification project should be examined for:

- a. Any potential new and unique failure mechanisms.
- b. Any situation where these tests/conditions may induce failures that would not be seen in the application.
- c. Any extreme use condition and/or application that could adversely reduce the acceleration.

Use of this document does not relieve the IC supplier of their responsibility to meet their own company's internal qualification program. In this document, "user" is defined as all customers using a device qualified per this specification. The user is responsible to confirm and validate all qualification data that substantiates conformance to this document. Supplier usage of the device temperature grades as stated in this specification in their part information is strongly encouraged.

**1.1 Purpose**

The purpose of this specification is to determine that a device is capable of passing the specified stress tests and thus can be expected to give a certain level of quality/reliability in the application.

**1.2 Reference Documents**

Current revision of the referenced documents will be in effect at the date of agreement to the qualification plan. Subsequent qualification plans will automatically use updated revisions of these referenced documents.

**1.2.1 Automotive**

AEC-Q001 Guidelines for Part Average Testing  
AEC-Q002 Guidelines for Statistical Yield Analysis  
AEC-Q003 Guidelines for Characterizing the Electrical Performance  
AEC-Q004 Zero Defects Guideline (DRAFT)  
AEC-Q005 Pb-Free Requirements  
SAE J1752/3 Integrated Circuits Radiated Emissions Measurement Procedure

**1.2.2 Military**

MIL-STD-883 Test Methods and Procedures for Microelectronics

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### **1.2.3 Industrial**

JEDEC JESD-22 Reliability Test Methods for Packaged Devices  
UL-STD-94 Tests for Flammability of Plastic materials for parts in Devices and Appliances  
IPC/JEDEC J-STD-020 Moisture/Reflow Sensitivity Classification for Plastic Integrated Circuit Surface Mount Devices  
JESD89 Measurement and Reporting of Alpha Particle and Terrestrial Cosmic Ray-Induced Soft Errors in Semiconductor Devices  
JESD89-1 System Soft Error Rate (SSER) Test Method  
JESD89-2 Test Method For Alpha Source Accelerated Soft Error Rate  
JESD89-3 Test Method for Beam Accelerated Soft Error Rate

### **1.2.4 Decommissioned**

AEC Q100-003 ESD Machine Model

- Removed from JEDEC due to obsolescence. HBM and CDM cover virtually all known ESD-related failure mechanisms.

AEC Q100-006 Electrothermally-Induced Gate Leakage

- Removed due to the lack of need for it as a qualification test.

### **1.3 Definitions**

#### **1.3.1 AEC Q100 Qualification**

Successful completion and documentation of the test results from requirements outlined in this document allows the supplier to claim that the part is "AEC Q100 qualified". For ESD, it is **highly recommended** that the passing voltage be specified in the supplier datasheet with a footnote on any pin exceptions. This will allow suppliers to state, e.g., "AEC-Q100 qualified to ESD Classification 2".

#### **1.3.2 AEC Certification**

Note that there are no "certifications" for AEC-Q100 qualification and there is no certification board run by AEC to qualify parts. Each supplier performs their qualification to AEC standards, considers customer requirements and submits the data to the customer to verify compliance to Q100.

#### **1.3.3 Approval for Use in an Application**

"Approval" is defined as user approval for use of a part in their application. The user's method of approval is beyond the scope of this document.



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**1.3.4 Definition of Part Operating Temperature Grade**

The part operating temperature grades are defined in Table 1 below:

**Table 1: Part Operating Temperature Grades**

<u>Grade</u>	<u>Ambient Operating Temperature Range</u>
<u>0</u>	<u>-40°C to +150°C</u>
<u>1</u>	<u>-40°C to +125°C</u>
<u>2</u>	<u>-40°C to +105°C</u>
<u>3</u>	<u>-40°C to +85°C</u>

The endpoint test temperatures for hot and cold test, if required for that stress test, must be equivalent to those specified for the particular grade. If accounting for junction heating during powered test, hot test endpoint test temperature can be greater.

For Test Group B – Accelerated Lifetime Simulation Tests: High Temperature Operating Life (HTOL), Early Life Failure Rate (ELFR) and NVM Endurance, Data Retention, and Operational Life (EDR), the junction temperature of the device during stressing should be equal to or greater than the hot temperature for that grade.

**1.3.5 Capability Measures Cpk**

Refer to AEC-Q003 Characterization to understand how the Cpk measure will be used in this standard.

**2. GENERAL REQUIREMENTS**

**2.1 Objective**

The objective of this specification is to establish a standard that defines operating temperature grades for integrated circuits based on a minimum set of qualification requirements.

**2.1.1 Zero Defects**

Qualification and some other aspects of this document are a subset of, and contribute to, the achievement of the goal of Zero Defects. Elements needed to implement a zero defects program can be found in AEC-Q004 Zero Defects Guideline.

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#### 2.2 Precedence of Requirements

In the event of conflict in the requirements of this standard and those of any other documents, the following order of precedence applies:

- a. The purchase order (or master purchase agreement terms and conditions)
- b. The (mutually agreed) individual device specification
- c. This document
- d. The reference documents in Section 1.2 of this document
- e. The supplier's data sheet

For the device to be considered a qualified part per this specification, the purchase order and/or the individual device specification cannot waive or detract from the requirements of this document.

#### 2.3 Use of Generic Data to Satisfy Qualification and Requalification Requirements

##### 2.3.1 Definition of Generic Data

The use of generic data to simplify the qualification process is strongly encouraged. Generic data can be submitted to the user as soon as it becomes available to determine the need for any additional testing. To be considered, the generic data must be based on a matrix of specific requirements associated with each characteristic of the device and manufacturing process as shown in Table 3 and Appendix 1. **If the generic data contains any failures, the data is not usable as generic data unless the supplier has documented and implemented corrective action or containment for the failure condition that is acceptable to the user.**

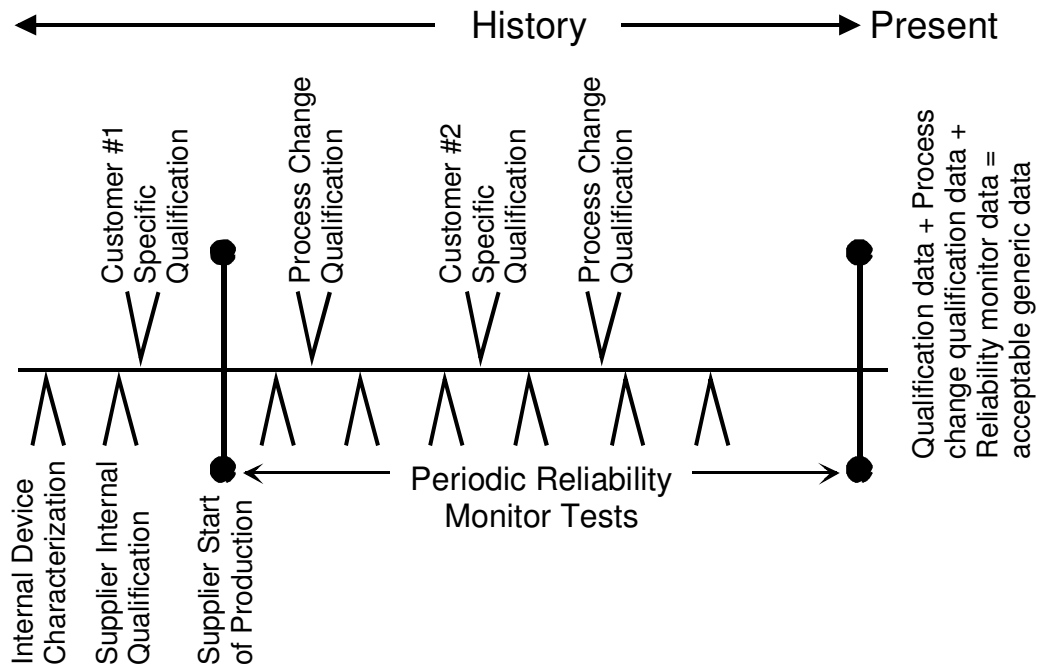
Appendix 1 defines the criteria by which components are grouped into a qualification family for the purpose of considering the data from all family members to be equal and generically acceptable for the qualification of the device in question. For each stress test, two or more qualification families can be combined if the reasoning is technically sound (i.e., supported by data).

Table 3 defines a set of qualification tests that must be considered for any changes proposed for the component. The Table 3 matrix is the same for both new processes and requalification associated with a process change. This table is a superset of tests that the supplier and user should use as a baseline for discussion of tests that are required for the qualification in question. **It is the supplier's responsibility to present rationale for why any of the recommended tests need not be performed.**

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**2.3.3 Time Limit for Acceptance of Generic Data**

There are no time limits for the acceptability of generic data. Use the diagram below for appropriate sources of reliability data that can be used. This data must come from the specific part or a part in the same qualification family, as defined in Appendix 1. Potential sources of data could include any customer specific data (withhold customer name), process change qualification, and periodic reliability monitor data (see Figure 1).



**Note:** Some process changes (e.g., die shrink) will affect the use of generic data such that data obtained before these types of changes will not be acceptable for use as generic data.

**Figure 1: Generic Data Time Line**

**2.4 Test Samples**

**2.4.1 Lot Requirements**

Test samples shall consist of a representative device from the qualification family. Where multiple lot testing is required due to a lack of generic data, test samples as indicated in Table 2 must be composed of approximately equal numbers from non-consecutive wafer lots, assembled in non-consecutive molding lots. That is, they must be separated in the fab or assembly process line by at least one non-qualification lot. Any deviation from the above requires technical explanation from the supplier.

**2.4.2 Production Requirements**

All qualification devices shall be produced on tooling and processes at the manufacturing site that will be used to support part deliveries at production volumes. Other electrical test sites may be used for electrical measurements after their electrical quality is validated.

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#### **2.4.3 Reusability of Test Samples**

Devices that have been used for nondestructive qualification tests may be used to populate other qualification tests. Devices that have been used for destructive qualification tests may not be used any further except for engineering analysis.

#### **2.4.4 Sample Size Requirements**

Sample sizes used for qualification testing and/or generic data submission must be consistent with the specified minimum sample sizes and acceptance criteria in Table 2.

If the supplier elects to use generic data for qualification, the specific test conditions and results must be recorded and available to the user (preferably in the format shown in Appendix 4). Existing applicable generic data should first be used to satisfy these requirements and those of Section 2.3 for each test requirement in Table 2. Device specific qualification testing should be performed if the generic data does not satisfy these requirements.

#### **2.4.5 Pre- and Post-stress Test Requirements**

End-point test temperatures (room, hot and/or cold) are specified in the "Additional Requirements" column of Table 2 for each test.

#### **2.5 Definition of Test Failure After Stressing**

Test failures are defined as those devices not meeting the individual device specification, criteria specific to the test, or the supplier's data sheet, in the order of significance as defined in Section 2.2. Any device that shows external physical damage attributable to the environmental test is also considered a failed device. If the cause of failure is due to mishandling during stressing or testing such as EOS or ESD, or some other cause unrelated to the component reliability, the failure shall be discounted but reported as part of the data submission.

### **3. QUALIFICATION AND REQUALIFICATION**

#### **3.1 Qualification of a New Device**

The stress test requirement flow for qualification of a new device is shown in Figure 2 with the corresponding test conditions defined in Table 2. For each qualification, the supplier must have data available for all of these tests, whether it is stress test results on the device to be qualified or acceptable generic data. A review shall also be made of other devices in the same generic family to ensure that there are no common failure mechanisms in that family. Justification for the use of generic data, whenever it is used, must be demonstrated by the supplier and approved by the user.

For each device qualification, the supplier must have available the following:

- Certificate of Design, Construction and Qualification (see Appendix 2)
- Stress Test Qualification data (see Table 2 & Appendix 4)
- Data indicating the level of fault grading of the software used for qualification (when applicable to the device type) per Q100-007 that will be made available to the customer upon request

#### **3.2 Requalification of a Changed Device**

Requalification of a device is required when the supplier makes a change to the product and/or process that impacts (or could potentially impact) the form, fit, function, quality and/or reliability of the device (see Table 3 for guidelines).

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## **3.2.1 Process Change Notification**

The supplier will meet the user requirements for product/process changes.

## **3.2.2 Changes Requiring Requalification**

As a minimum, any change to the product, as defined in Appendix 1, requires performing the applicable tests listed in Table 2, using Table 3 to determine the requalification test plan. Table 3 should be used as a guide for determining which tests are applicable to the qualification of a particular part change or whether equivalent generic data can be submitted for that test(s).

## **3.2.3 Criteria for Passing Requalification**

All requalification failures shall be analyzed for root cause. **Only when corrective and preventative actions are in place, the part may then be considered AEC Q100 qualified again.**

## **3.2.4 User Approval**

A change may not affect a device's operating temperature grade, but may affect its performance in an application. Individual user authorization of a process change will be required for that user's particular application(s), and this method of authorization is outside the scope of this document.

## **3.3 Qualification of a Pb-Free Device**

Added requirements needed to address the special quality and reliability issues that arise when Lead (Pb)-Free processing is utilized is specified in AEC-Q005 Pb-Free Requirements. Materials used in Pb-Free processing include the termination plating and the board attach (solder). These new materials usually require higher board attach temperatures to yield acceptable solder joint quality and reliability. These higher temperatures may adversely affect the moisture sensitivity level of plastic packaged semiconductors. As a result, new, more robust mold compounds may be required. If an encapsulation material change is required to provide adequate robustness for Pb-Free processing of the device, the supplier should refer to the process change qualification requirements in this specification. Preconditioning should be performed at the Pb-free reflow classification temperatures described in IPC/JEDEC J-STD-020 Moisture/Reflow Sensitivity Classification for Non-Hermetic Solid State Surface Mount Devices before environmental stress tests.

## **4. QUALIFICATION TESTS**

### **4.1 General Tests**

Test flows are shown in Figure 2 and test details are given in Table 2. Not all tests apply to all devices. For example, certain tests apply only to ceramic packaged devices, others apply only to devices with NVM, and so on. The applicable tests for the particular device type are indicated in the "Note" column of Table 2. The "Additional Requirements" column of Table 2 also serves to highlight test requirements that supersede those described in the referenced test method. Any unique qualification tests or conditions requested by the user and not specified in this document shall be negotiated between the supplier and user requesting the test.

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#### **4.2 Device Specific Tests**

The following tests must be performed on the specific device to be qualified for all hermetic and plastic packaged devices. Generic data is not allowed for these tests. Device specific data, if it already exists, is acceptable.

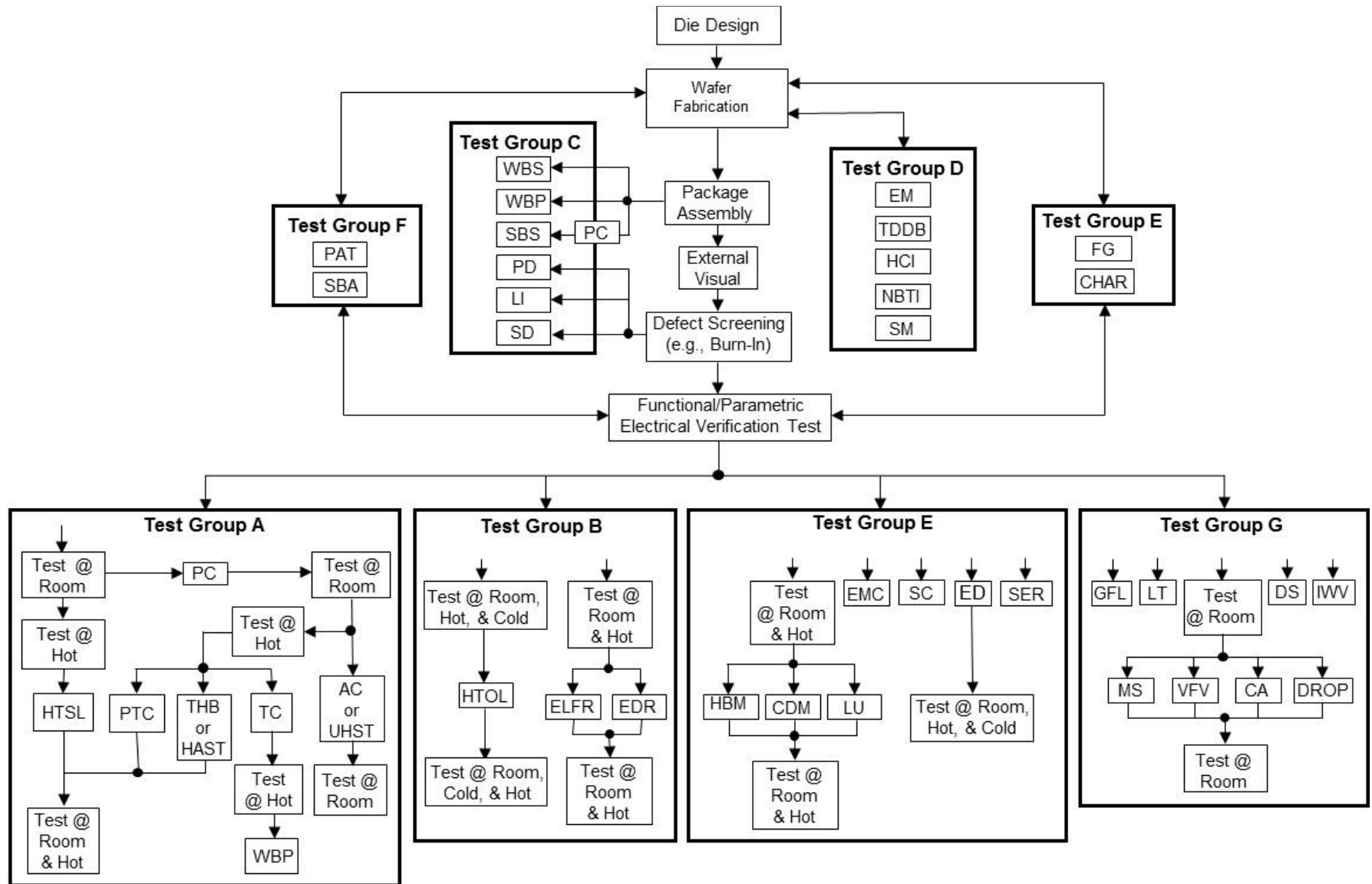
1. Electrostatic Discharge (ESD) - All product.
2. Latch-up (LU) - All product.
3. Electrical Distribution - The supplier must demonstrate, over the operating temperature grade, voltage, and frequency, that the device is capable of meeting the parametric limits of the device specification. This data must be taken from at least three lots, or one matrixed (or skewed) process lot, and must represent enough samples to be statistically valid, see Q100-009. It is strongly recommended that the final test limits be established using AEC-Q001 Guidelines For Part Average Testing.
4. Other Tests - A user may require other tests in lieu of generic data based on his experience with a particular supplier.

#### **4.3 Wearout Reliability Tests**

Testing for the failure mechanisms listed below must be available to the user whenever a new technology or material relevant to the appropriate wearout failure mechanism is to be qualified. The data, test method, calculations, and internal criteria need not be demonstrated or performed on the qualification of every new device, but should be available to the user upon request.

- Electromigration
- Time-Dependent Dielectric Breakdown (or Gate Oxide Integrity Test) - for all MOS technologies
- Hot Carrier Injection - for all MOS technologies below 1 micron
- Negative Bias Temperature Instability
- Stress Migration

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**Figure 2: Qualification Test Flow**

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**Table 2: Qualification Test Methods**

<b>TEST GROUP A – ACCELERATED ENVIRONMENT STRESS TESTS</b>								
<b>STRESS</b>	<b>ABV</b>	<b>#</b>	<b>NOTES</b>	<b>SAMPLE SIZE / LOT</b>	<b>NUMBER OF LOTS</b>	<b>ACCEPT CRITERIA</b>	<b>TEST METHOD</b>	<b>ADDITIONAL REQUIREMENTS</b>
<b>Preconditioning</b>	<b>PC</b>	A1	P, B, S, N, G	77	3	0 Fails	JEDEC J-STD-020 JESD22-A113	Performed on surface mount devices only. PC performed before THB/HAST, AC/UHST, TC, and PTC stresses. It is recommended that J-STD-020 be performed to determine what preconditioning level to perform in the actual PC stress per JA113. The minimum acceptable level for qualification is level 3 per JA113. Where applicable, preconditioning level and Peak Reflow Temperature must be reported when preconditioning and/or MSL is performed. Delamination from the die surface in JA113/J-STD-020 is acceptable if the device passes the subsequent Qualification tests. Any replacement of devices must be reported. <b>TEST before and after PC at room temperature.</b>
<b>Temperature-Humidity-Bias or Biased HAST</b>	<b>THB or HAST</b>	A2	P, B, D, G	77	3	0 Fails	JEDEC JESD22-A101 or A110	For surface mount devices, PC before THB (85°C/85%RH for 1000 hours) or HAST (130°C/85%RH for 96 hours, or 110°C/85%RH for 264 hours). <b>TEST before and after THB or HAST at room and hot temperature.</b>
<b>Autoclave or Unbiased HAST or Temperature-Humidity (without Bias)</b>	<b>AC or UHST or TH</b>	A3	P, B, D, G	77	3	0 Fails	JEDEC JESD22-A102, A118, or A101	For surface mount devices, PC before AC (121°C/15psig for 96 hours) or unbiased HAST (130°C/85%RH for 96 hours, or 110°C/85%RH for 264 hours). For packages sensitive to high temperatures and pressure (e.g., BGA), PC followed by TH (85°C/85%RH) for 1000 hours may be substituted. <b>TEST before and after AC, UHST, or TH at room temperature.</b>



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Table 2: Qualification Test Methods (continued)

TEST GROUP A – ACCELERATED ENVIRONMENT STRESS TESTS (CONTINUED)								
STRESS	ABV	#	NOTES	SAMPLE SIZE / LOT	NUMBER OF LOTS	ACCEPT CRITERIA	TEST METHOD	ADDITIONAL REQUIREMENTS
Temperature Cycling	TC	A4	H, P, B, D, G	77	3	0 Fails	JEDEC JESD22-A104 and Appendix 3	<p>PC before TC for surface mount devices.  <b>Grade 0:</b> -55°C to +150°C for 2000 cycles <u>or equivalent</u>.  <b>Grade 1:</b> -55°C to +150°C for 1000 cycles <u>or equivalent</u>.  <b>Note:</b> -65°C to 150°C for 500 cycles is also an allowed test condition due to legacy use with no known lifetime issues.  <b>Grade 2:</b> -55°C to +125°C for 1000 cycles <u>or equivalent</u>.  <b>Grade 3:</b> -55°C to +125°C for 500 cycles <u>or equivalent</u>.</p> <p><b>TEST before and after TC at hot temperature.</b> After completion of TC, decap five devices from one lot and perform WBP (test #C2) on corner bonds (2 bonds per corner) and one mid-bond per side <b>on each device</b>. Preferred decap procedure to minimize damage and chance of false data is shown in Appendix 3.</p>
Power Temperature Cycling	PTC	A5	H, P, B, D, G	45	1	0 Fails	JEDEC JESD22-A105	<p>PC before PTC for surface mount devices. Test required only on devices with maximum rated power <math>\geq 1</math> watt or <math>\Delta T_J \geq 40^\circ\text{C}</math> or devices designed to drive inductive loads.  <b>Grade 0:</b> <math>T_a</math> of -40°C to +150°C for 1000 cycles.  <b>Grade 1:</b> <math>T_a</math> of -40°C to +125°C for 1000 cycles.  <b>Grades 2 and 3:</b> <math>T_a</math> -40°C to +105°C for 1000 cycles.                      Thermal shut-down shall not occur during this test. <b>TEST before and after PTC at room and hot temperature.</b></p>
High Temperature Storage Life	HTSL	A6	H, P, B, D, G, K	45	1	0 Fails	JEDEC JESD22-A103	<p><b>Plastic Packaged Parts</b>  <b>Grade 0:</b> +175°C <math>I_a</math> for 1000 hours or +150°C <math>I_a</math> for 2000 hours.  <b>Grade 1:</b> +150°C <math>I_a</math> for 1000 hours or +175°C <math>I_a</math> for 500 hours.  <b>Grades 2 and 3:</b> +125°C <math>I_a</math> for 1000 hours or +150°C <math>I_a</math> for 500 hours.  <b>Ceramic Packaged Parts</b>                      +250°C <math>I_a</math> for 10 hours or +200°C <math>I_a</math> for 72 hours.  <b>TEST before and after HTSL at room and hot temperature.</b>                      * <b>NOTE:</b> Data from Test B3 (EDR) can be substituted for Test A6 (HTSL) if package and grade level requirements are met.</p>

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**Table 2: Qualification Test Methods (continued)**

TEST GROUP B – ACCELERATED LIFETIME SIMULATION TESTS								
STRESS	ABV	#	NOTES	SAMPLE SIZE / LOT	NUMBER OF LOTS	ACCEPT CRITERIA	TEST METHOD	ADDITIONAL REQUIREMENTS
<b>High Temperature Operating Life</b>	HTOL	B1	H, P, B, D, G, K	77	3	0 <u>Fails</u>	JEDEC JESD22-A108	For devices containing NVM, endurance preconditioning must be performed before HTOL per Q100-005. <b>Grade 0:</b> +150°C T <sub>a</sub> for 1000 hours. <b>Grade 1:</b> +125°C T <sub>a</sub> for 1000 hours. <b>Grade 2:</b> +105°C T <sub>a</sub> for 1000 hours. <b>Grade 3:</b> +85°C T <sub>a</sub> for 1000 hours.  HTOL NOTES: 1) <u>HTOL stress times for the appropriate grade T<sub>a</sub> are the min requirement; the T<sub>i</sub> of the test (measured or calculated) should be available.</u> 2) <u>T<sub>i</sub> may be used instead of T<sub>a</sub> when performing HTOL provided that T<sub>i</sub> of the device under HTOL conditions is equal to or higher than the T<sub>i</sub> maximum operating (T<sub>ipmax</sub>) of the particular device, but below the absolute maximum T<sub>i</sub>.</u> 3) <u>If T<sub>i</sub> is used to set the HTOL conditions, the minimum stress of 1000 hours at the T<sub>a</sub> of the device is to be shown using activation energy of 0.7ev or other value technically justified.</u> 4) <u>V<sub>cc</sub> (max) at which dc and ac parametrics are guaranteed. Thermal shut-down shall not occur during this test. <b>TEST before and after HTOL at room, cold, and hot temperature (in that order).</b></u>
<b>Early Life Failure Rate</b>	ELFR	B2	H, P, B, N, G	800	3	0 <u>Fails</u>	AEC Q100-008	Devices that pass this stress can be used to populate other stress tests. Generic data is applicable. <b>TEST before and after ELFR at room and hot temperature.</b>
<b>NVM Endurance, Data Retention, and Operational Life</b>	EDR	B3	H, P, B, D, G, K	77	3	0 <u>Fails</u>	AEC Q100-005	<b>TEST before and after EDR at room and hot temperature. Sample size and lot requirement applies to EACH of the NVM tests per Q100-005.</b>

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**Table 2: Qualification Test Methods (continued)**

<b>TEST GROUP C – PACKAGE ASSEMBLY INTEGRITY TESTS</b>								
STRESS	ABV	#	NOTES	SAMPLE SIZE / LOT	NUMBER OF LOTS	ACCEPT CRITERIA	TEST METHOD	ADDITIONAL REQUIREMENTS
Wire Bond Shear	WBS	C1	H, P, D, G	30 bonds from a minimum of 5 devices		$C_{PK} > 1.67$	AEC Q100-001 <u>AEC Q003</u>	At appropriate time interval for each bonder to be used.
Wire Bond Pull	WBP	C2	H, P, D, G			$C_{PK} > 1.67$ or 0 Fails after TC (test #A4)	MIL-STD883 Method 2011 <u>AEC Q003</u>	Condition C or D. For Au wire diameter $\geq 1$ mil, minimum pull strength after TC = 3 grams. For Au wire diameter $< 1$ mil, refer to Figure 2011-1 in MIL-STD-883 Method 2011 as a guideline for minimum pull strength. For Au wire diameter $< 1$ mil, wire bond pull shall be performed with the hook over the ball bond and not at mid-wire.
Solderability	SD	C3	H, P, D, G	15	1	$> 95\%$ lead coverage	JEDEC JESD22-B102 or <u>JEDEC J-STD-002D</u>	If burn-in screening is normally performed on the device before shipment, samples for SD must first undergo burn-in. Perform 8 hour steam aging prior to testing (1 hour for Au-plated leads). <u>The customer can request justification for using dry bake in place of steam aging.</u>
Physical Dimensions	PD	C4	H, P, D, G	10	3	$C_{PK} > 1.67$	JEDEC JESD22-B100 and B108 <u>AEC Q003</u>	See applicable JEDEC standard outline and individual device spec for significant dimensions and tolerances.
Solder Ball Shear	SBS	C5	B	5 balls from a min. of 10 devices	3	$C_{PK} > 1.67$	AEC Q100-010 <u>AEC Q003</u>	PC thermally (two 220°C reflow cycles) before integrity (mechanical) testing. <u>Refer to J-STD-020 for Pb-free reflow profiles to be used for this test.</u>
Lead Integrity	LI	C6	H, P, D, G	10 leads from each of 5 parts	1	No lead breakage or cracks	JEDEC JESD22-B105	Not required for surface mount devices. Only required for through-hole devices.
<b>TEST GROUP D – DIE FABRICATION RELIABILITY TESTS</b>								
STRESS	ABV	#	NOTES	SAMPLE SIZE / LOT	NUMBER OF LOTS	ACCEPT CRITERIA	TEST METHOD	ADDITIONAL REQUIREMENTS
Electromigration	EM	D1	---	---	---	---	---	The data, test method, calculations and internal criteria should be available to the user upon request for new technologies.
Time Dependent Dielectric Breakdown	Tddb	D2	---	---	---	---	---	The data, test method, calculations and internal criteria should be available to the user upon request for new technologies.

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**Table 2: Qualification Test Methods (continued)**

<b>TEST GROUP D – DIE FABRICATION RELIABILITY TESTS (CONTINUED)</b>								
<b>STRESS</b>	<b>ABV</b>	<b>#</b>	<b>NOTES</b>	<b>SAMPLE SIZE / LOT</b>	<b>NUMBER OF LOTS</b>	<b>ACCEPT CRITERIA</b>	<b>TEST METHOD</b>	<b>ADDITIONAL REQUIREMENTS</b>
<b>Hot Carrier Injection</b>	<b>HCI</b>	D3	---	---	---	---	---	The data, test method, calculations and internal criteria should be available to the user upon request for new technologies.
<b>Negative Bias Temperature Instability</b>	<b>NBTI</b>	D4	---	---	---	---	---	The data, test method, calculations and internal criteria should be available to the user upon request for new technologies.
<b>Stress Migration</b>	<b>SM</b>	D5	---	---	---	---	---	The data, test method, calculations and internal criteria should be available to the user upon request for new technologies.
<b>TEST GROUP E – ELECTRICAL VERIFICATION TESTS</b>								
<b>STRESS</b>	<b>ABV</b>	<b>#</b>	<b>NOTES</b>	<b>SAMPLE SIZE / LOT</b>	<b>NUMBER OF LOTS</b>	<b>ACCEPT CRITERIA</b>	<b>TEST METHOD</b>	<b>ADDITIONAL REQUIREMENTS</b>
<b>Pre- and Post-Stress Function/Parameter</b>	<b>TEST</b>	E1	H, P, B, N, G	All	All	0 Fails	Test program to supplier data sheet or user specification	Test is performed as specified in the applicable stress reference and the additional requirements in Table 2 and illustrated in Figure 2. Test software used shall meet the requirements of Q100-007. All electrical testing before and after the qualification stresses are performed to the limits of the individual device specification in temperature and limit value.
<b>Electrostatic Discharge Human Body Model</b>	<b>HBM</b>	E2	H, P, B, D	See Test Method	1	Target: 0 Fails 2KV HBM (Classification 2 or better)	AEC Q100-002	<b>TEST before and after ESD at room and hot temperature.</b> Device shall be classified according to the maximum withstand voltage level. Device levels <2000V HBM require specific user approval. <u>Refer to Section 1.3.1.</u>
<b>Electrostatic Discharge Charged Device Model</b>	<b>CDM</b>	E3	H, P, B, D	See Test Method	1	Target: 0 Fails 750V corner pins, 500V all other pins (Classification C4B or better)	AEC Q100-011	<b>TEST before and after ESD at room and hot temperature.</b> Device shall be classified according to the maximum withstand voltage level. Device levels <750V corner pins and/or <500V all other pins CDM require specific user approval. <u>Refer to Section 1.3.1.</u>

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**Table 2: Qualification Test Methods (continued)**

TEST GROUP E – ELECTRICAL VERIFICATION TESTS (CONTINUED)								
STRESS	ABV	#	NOTES	SAMPLE SIZE / LOT	NUMBER OF LOTS	ACCEPT CRITERIA	TEST METHOD	ADDITIONAL REQUIREMENTS
<b>Latch-Up</b>	<b>LU</b>	E4	H, P, B, D	6	1	0 Fails	AEC Q100-004	See attached procedure for details on how to perform the test. <b>TEST before and after LU at room and hot temperature.</b>
<b>Electrical Distributions</b>	<b>ED</b>	E5	H, P, B, D	30	3	Where applicable, $C_{PK} > 1.67$	AEC Q100-009 AEC Q003	Supplier and user to mutually agree upon electrical parameters to be measured and accept criteria. <b>TEST at room, hot, and cold temperature.</b>
<b>Fault Grading</b>	<b>FG</b>	E6	---	---	---	AEC Q100-007 unless otherwise specified	AEC Q100-007	For production testing, see Q100-007 for test requirements.
<b>Characterization</b>	<b>CHAR</b>	E7	---	---	---	---	AEC Q003	To be performed on new technologies and part families.
<b>Electromagnetic Compatibility</b>	<b>EMC</b>	E9	---	1	1	---	SAE J1752/3 – Radiated Emissions	See Appendix 5 for guidelines on determining the applicability of this test to the device to be qualified. This test and its accept criteria is performed per agreement between user and supplier on a case-by-case basis.
<b>Short Circuit Characterization</b>	<b>SC</b>	E10	D, G	10	3	0 Fails	AEC Q100-012	<b>Applicable to all smart power devices.</b> This test and statistical evaluation (see Section 4 of Q100-012) shall be performed per agreement between user and supplier on a case-by-case basis.
<b>Soft Error Rate</b>	<b>SER</b>	E11	H, P, D, G	3	1	---	JEDEC Un-accelerated: JESD89-1 or Accelerated: JESD89-2 & JESD89-3	<b>Applicable to devices with memory sizes <math>\geq 1\text{Mbit}</math> SRAM or DRAM based cells.</b> Either test option (un-accelerated or accelerated) can be performed, in accordance to the referenced specifications. This test and its accept criteria is performed per agreement between user and supplier on a case-by-case basis. Final test report shall include detailed test facility location and altitude data.
<b><u>Lead (Pb) Free</u></b>	<b><u>LF</u></b>	<b><u>E12</u></b>	<b><u>L</u></b>	<b><u>See Test Method</u></b>	<b><u>See Test Method</u></b>	<b><u>See Test Method</u></b>	<b><u>AEC Q005</u></b>	<b><u>Applicable to ALL Pb-free devices. Note the recommendations for all related solderability, solder heat resistance and whisker requirements.</u></b>

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**Table 2: Qualification Test Methods (continued)**

<b>TEST GROUP F – DEFECT SCREENING TESTS</b>								
<b>STRESS</b>	<b>ABV</b>	<b>#</b>	<b>NOTES</b>	<b>SAMPLE SIZE / LOT</b>	<b>NUMBER OF LOTS</b>	<b>ACCEPT CRITERIA</b>	<b>TEST METHOD</b>	<b>ADDITIONAL REQUIREMENTS</b>
<b>Process Average Testing</b>	<b>PAT</b>	F1	---	---	---	---	AEC Q001	<u>The supplier determines the sample sizes and accept criteria per the test methods. If these tests are not possible for a given part, the supplier must provide justification. The supplier determines the sample sizes and accept criteria per the test methods. If these tests are not possible for a given part, the supplier must provide justification. The supplier must perform some variant of PAT and SBA that meets the intent of the guideline.</u>
<b>Statistical Bin/Yield Analysis</b>	<b>SBA</b>	F2	---	---	---	---	AEC Q002	
<b>TEST GROUP G – CAVITY PACKAGE INTEGRITY TESTS</b>								
<b>STRESS</b>	<b>ABV</b>	<b>#</b>	<b>NOTES</b>	<b>SAMPLE SIZE / LOT</b>	<b>NUMBER OF LOTS</b>	<b>ACCEPT CRITERIA</b>	<b>TEST METHOD</b>	<b>ADDITIONAL REQUIREMENTS</b>
<b>Mechanical Shock</b>	<b>MS</b>	G1	H, D, G	<u>15</u>	<u>1</u>	0 Fails	JEDEC JESD22-B104	Y1 plane only, 5 pulses, 0.5 msec duration, 1500 g peak acceleration. <b>TEST before and after at room temperature.</b>
<b>Variable Frequency Vibration</b>	<b>VFV</b>	G2	H, D, G	<u>15</u>	<u>1</u>	0 Fails	JEDEC JESD22-B103	20 Hz to 2 KHz to 20 Hz (logarithmic variation) in >4 minutes, 4X in each orientation, 50 g peak acceleration. <b>TEST before and after at room temperature.</b>
<b>Constant Acceleration</b>	<b>CA</b>	G3	H, D, G	<u>15</u>	<u>1</u>	0 Fails	MIL-STD-883 Method 2001	Y1 plane only, 30 K g-force for <40 pin packages, 20 K g-force for 40 pins and greater. <b>TEST before and after at room temperature.</b>
<b>Gross/Fine Leak</b>	<b>GFL</b>	G4	H, D, G	<u>15</u>	<u>1</u>	0 Fails	MIL-STD-883 Method 1014	Any single-specified fine test followed by any single-specified gross test. For ceramic packaged cavity devices only.
<b>Package Drop</b>	<b>DROP</b>	G5	H, D, G	5	1	0 Fails	---	Drop part on each of 6 axes once from a height of 1.2m onto a concrete surface. This test is for MEMS cavity devices only. <b>TEST before and after DROP at room temperature.</b>
<b>Lid Torque</b>	<b>LT</b>	G6	H, D, G	5	1	0 Fails	MIL-STD-883 Method 2024	For ceramic packaged cavity devices only.
<b>Die Shear</b>	<b>DS</b>	G7	H, D, G	5	1	0 Fails	MIL-STD-883 Method 2019	To be performed before cap/seal for all cavity devices.
<b>Internal Water Vapor</b>	<b>IWV</b>	G8	H, D, G	<u>5</u>	1	0 Fails	MIL-STD-883 Method 1018	For ceramic packaged cavity devices only.

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**Legend for Table 2**

- Notes: **H** Required for hermetic packaged devices only.  
**P** Required for plastic packaged devices only.  
**B** Required Solder Ball Surface Mount Packaged (BGA) devices only.  
**N** Nondestructive test, devices can be used to populate other tests or they can be used for production.  
**D** Destructive test, devices are not to be reused for qualification or production.  
**S** Required for surface mount plastic packaged devices only.  
**G** Generic data allowed. See Section 2.3 and Appendix 1.  
**K** Use method AEC-Q100-005 for preconditioning a stand-alone Non-Volatile Memory integrated circuit or an integrated circuit with a Non-Volatile Memory module.  
**L** Required for Pb-free devices only.
- #** Reference Number for the particular test.
- \*** All electrical testing before and after the qualification stresses are performed to the limits of the individual device specification in temperature and limit value.

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**Table 3: Process Change Qualification Guidelines for the Selection of Tests**

A2 Temperature Humidity Bias or HAST	C4 Physical Dimensions	E5 Electrical Distribution
A3 Autoclave or Unbiased HAST	C5 Solder Ball Shear	E7 Characterization
A4 Temperature Cycling	C6 Lead Integrity	E9 Electromagnetic Compatibility
A5 Power Temperature Cycling	D1 Electromigration	E10 Short Circuit Characterization
A6 High Temperature Storage Life	D2 Time Dependent Dielectric Breakdown	E11 Soft Error Rate
B1 High Temperature Operating Life	D3 Hot Carrier Injection	<u>E12 Lead Free</u>
B2 Early Life Failure Rate	D4 Negative Bias Temperature Instability	G1-4 Mechanical Series
B3 NVM Endurance, Data Retention	D5 Stress Migration	G5 Package Drop
C1 Wire Bond Shear	E2 Human Body Model ESD	G6 Lid Torque
C2 Wire Bond Pull	E3 Charged Device Model ESD	G7 Die Shear
C3 Solderability	E4 Latch-up	G8 Internal Water Vapor

**Note:** A letter or "●" indicates that performance of that stress test should be **considered** for the appropriate process change. Reason for not performing a considered test should be given in the qualification plan or results.

Table 2 Test #	A2	A3	A4	A5	A6	B1	B2	B3	C1	C2	C3	C4	C5	C6	D1	D2	D3	D4	D5	E2	E3	E4	E5	E7	E9	E10	E11	<u>E12</u>	G1-4	G5	G6	G7	G8						
Test Abbreviation	THB	AC	TC	PTC	HTSL	HTOL	ELFR	EDR	WBS	WBP	SD	PD	SBS	LI	EM	TDDB	HCI	NBTI	SM	HBM	CDM	LU	ED	CHAR	EMC	SC	SER	<u>LF</u>	MECH	DROP	LT	DS	IWV						
<b>DESIGN</b>																																							
Active Element Design		●	●	M		●	●	DJ							D	D	D	D	D	●	●	●	●	●	●	●	●						F						
Circuit Rerouting			A	M																●	●	●	●	●	●	●	●												
Wafer Dimension / Thickness			E	M		●	●		E	E								●		E	E	E	●																
<b>WAFER FAB</b>																																							
Lithography	●		●	M		●	G		●	●								●					●																
Die Shrink	●	●		M		●	●	DJ							●	●	●	●	●	●	●	●	●	●	●	●	●	●											
Diffusion/Doping				M		●	G											●		●	●	●	●	●	●	●	●												
Polysilicon			●	M		●		DJ										●		●	●	●	●	●	●	●	●												
Metallization / Vias / Contacts	●	●	●	M		●			●	●					●				●				●	●		●													
Passivation / Oxide / Interlevel Dielectric	K	K	●	M		●	GN	DJ	K	●						●	●	●	●	●	●	●	●	●	●	●	●												
Backside Operation			●	M		●														M	M	●	●							H				H					
FAB Site Transfer	●	●	●	M		●	●	J	●	●					●	●	●	●	●	●	●	●	●	●	●	●	●			H					H				
<b>ASSEMBLY</b>																																							
Die Overcoat / Underfill	●	●	●	M	●	●																													H				
Leadframe Plating	●	●	●	M	●					C	●			●																						H			
Bump Material / Metal System	●	●	●	M	●	●						●	●														●												
Leadframe Material		●	●	M	●						●	●	●		●												●									H			
Leadframe Dimension		●	●	M							●	●		●													●									H			
Wire Bonding	●	●	●	Q	●				●	●													M			●													
Die Scribe/Separate	●	●	●	M																																			
Die Preparation / Clean	●	●		M		●			●	●																											H		
Package Marking											B																												
Die Attach	●	●	●	M		●																	●			●											H	H	
Molding Compound	●	●	●	M	●	●	●				●	●		●													●												
Molding Process	●	●	●	M	●	●					●	●		●																									
Hermetic Sealing		H	H		H							H		H																							H	H	
New Package	●	●	●	M	●	●	●		●	●	●	●	T	●						●	●		●			●												H	H
Substrate / Interposer	●	●	●	M	●	●			●	●			T																									H	H
Assembly Site Transfer	●	●	●	M		●	●		●	●	●	●	T	●									●															H	H

- |  |                                      |                                   |
|--|--------------------------------------|-----------------------------------|
| A Only for peripheral routing            | F MEMS element only                  | <u>L</u> For Pb-free devices only |
| B For symbol rework, new cure time, temp | G Only from non-100% burned-in parts | M For devices requiring PTC       |
| C If bond to leadfinger                  | H Hermetic only                      | N Passivation and gate oxide      |
| D Design rule change                     | J EPROM or E <sup>2</sup> PROM       | Q Wire diameter decrease          |
| E Thickness only                         | K Passivation only                   | T For Solder Ball SMD only        |



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## **Appendix 1: Definition of a Product Qualification Family**

AECQ100 provides the following guideline for use of generic data to accelerate and streamline the qualification process for suppliers and customers. Suppliers and customers can use this guideline to reach mutual agreement on how to utilize generic data when it is appropriate.

For devices to be categorized in a product qualification family, they all must share the same major product, process and materials elements as defined below. The qualification of a particular product will be defined within, but not limited to, the categories listed below. Critical product functional details as defined in Section A1.1 and critical process steps and materials as defined in Sections A1.2 and A1.3 do not need to be matched exactly, but shall cover worst cases in application of the family generic data through technical justification.

All products in the same product qualification family are qualified by association when one family member successfully completes qualification with the exception of the device specific requirements of Section 4.2.

For broad changes that involve multiple attributes (e.g., site, materials, processes), refer to Section A1.5 of this appendix and Section 2.3 of Q100, which allows for the selection of worst-case test vehicles to cover all the possible permutations.

### **A1.1 Product**

- a. Product functionality (e.g., Op-Amp, regulator, microprocessor, Logic - HC/TTL)
- b. Operating supply voltage range(s)
- c. Specified operating temperature range
- d. Specified operating frequency range
- e. Design library cells for the fab technology
  - Memory IP (e.g., cell structure, building block)
  - Digital design library cells (e.g., circuit blocks, IO modules, ESD cells) and/or analog design library cells (e.g., active circuit elements, passive circuit elements) at data sheet voltage level(s) and at data sheet or better temperature range, and power dissipation
  - Speed/performance of the library cells
- f. Memory type(s) and sizes
- g. Design rules for active circuits under pads
- h. Other functional characteristics as defined by supplier

For parts specified to operate at different power supplies (e.g., 5.0 V and 3.3 V), product qualification family data should be presented for both supply ranges.

For parts specified to operate at different temperature range, three (3) lots of data from the product qualification family at the temperature of the device in the data sheet need to be presented with Table 2 E1 TEST data. Stress classification at the temperature specified Q100 Table 2 groups A, B, E, and G must be equal or higher than device qualified. Three (3) lots of data from the product family at the frequency of the device in the data sheet need to be presented with Table 2 E1 TEST data at the temperature specified Q100 Table 2 groups A, B, E, and G. All memory types must be demonstrated to be qualified over three (3) lots using largest memory size to be qualified for devices in the family. If the part to be qualified has a larger memory size than the one already qualified, the supplier must perform at least one lot of testing on the larger memory configuration.

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### **A1.2 Fab Process**

Each process technology (e.g., CMOS, NMOS, Bipolar) must be considered and qualified separately. No matter how similar, processes from one fundamental fab technology cannot be used for another. For BiCMOS devices, data must be taken from the appropriate technology based on the circuit under consideration.

“Worst case” family requalification with the appropriate tests is required when the process or a material is changed (see Table A1 for guidelines). The important attributes defining a fab process are listed below:

- a. **Wafer Fab Technology** (e.g., CMOS, NMOS, Bipolar)
- b. **Wafer Fab Process** - consisting of the same attributes listed below:
  - Circuit element feature size (e.g., layout design rules, die shrinks, contacts, gates, isolations)
  - Substrate (e.g., orientation, doping, epi, wafer size)
  - Number of masks (supplier must show justification for waiving this requirement)
  - Lithographic process (e.g., contact vs. projection, E-beam vs. X-ray, photoresist polarity)
  - Doping process (e.g., diffusion vs. ion implantation)
  - Gate structure, material and process (e.g., polysilicon, metal, salicide, wet vs. dry etch)
  - Polysilicon material, thickness range & number of levels
  - Oxidation process and thickness range (e.g., gate & field oxides)
  - Interlayer dielectric material & thickness range
  - Metallization material, thickness range & number of levels
  - Passivation process (e.g., passivation oxide opening), material, & thickness range
  - Die backside preparation process & metallization
- c. **Wafer Fab Site**

### **A1.3 Assembly Process - Plastic or Ceramic**

The processes for plastic and ceramic package technologies must be considered and qualified separately. For devices to be categorized in a qualification family, they all must share the same major process and material elements as defined below. Family requalification with the appropriate tests is required when the process or a material is changed. The supplier must submit technical justification to the user to support the acceptance of generic data with pin (ball) counts, die sizes, substrate dimensions/material/thickness, paddle sizes and die aspect ratios different than the device to be qualified. The supplier must possess technical data to justify the acceptance of generic data. The important attributes defining a qualification family are listed below:

- a. **Package Type** (e.g., DIP, SOIC, PLCC, QFP, PGA, PBGA)
  - Worst case within same package type (e.g., package warpage due to coefficients of thermal expansion mismatch)
  - Range of paddle (flag) size (maximum & minimum dimensions) qualified for the die size/aspect ratio under consideration
  - Substrate base material (e.g., PBGA)
- b. **Assembly Process** - consisting of the same attributes listed below:
  - Leadframe base material
  - Leadframe plating process & material (internal & external to the package)
  - Die header / Thermal pad material
  - Die attach material
  - Wire bond material & diameter
  - Wire bond method, presence of downbonds, & process

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- Plastic mold compound material, organic substrate material, or ceramic package material
- Solder Ball metallization system (if applicable)
- Heatsink type, material, & dimensions
- Plastic Mold Compound Supplier/ID
- Die Preparation/Singulation

c. **Assembly Site**

**A1.4 Qualification/Requalification Lot Requirements**

**Table A1.1: Part Qualification/Requalification Lot Requirements**

<b>Part Information</b>	<b>Lot Requirements for Qualification</b>
New device and no applicable generic data.	Lot and sample size requirements per Table 2.
A part in a <u>product family is qualified with 3 lots of generic data</u> . The part to be qualified is less complex and meets the <u>product Family Qualification Definition per Appendix 1</u> .	Only device specific tests as defined in <u>Section 4.2</u> are required. Lot and sample size requirements per Table 2 for the required tests.
A part in a <u>product family is qualified with 3 lots of generic data</u> . The part to be qualified is <u>slightly more complex, with similar product functionality, meeting the product family qualification definition per Appendix 1</u> . <u>Examples for one (1) lot wafer / assembly qualification, would be, increasing ADC performance from 12 to 14 bits or package pin count from 16 to 20</u> .	<u>Review Table 3 to determine which tests from Table 2 should be considered. One (1) lot wafer / assembly lot and sample sizes per Table 2 for the required tests.</u>
Part process change.	Review Table 3 to determine which tests from Table 2 should be considered. Lot and sample sizes per Table 2 for the required tests.
Part was environmentally tested to all the test extremes, but was electrically end-point tested at a temperature less than the Grade required.	The electrical end-point testing on at least <u>3 lots</u> (that completed qualification testing) must meet or exceed the temperature extremes for the device Grade required. Sample sizes shall be per Table 2.
Qualification/Requalification involving multiple sites.	Refer to Appendix 1, <u>Section A1.5</u> .
Qualification/Requalification involving multiple families.	Refer to Appendix 1, <u>Section A1.5</u> .

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**Table A1.2: Examples for Generic Data Use**

The cases listed in the generic data portion of the table signify those scenarios in which a product and site combination has been previously qualified and generic data exists. The use options of generic data described in each case define the allowable generic data for device  $A_n$  in the qualification portion of the table.

Guidelines for using Table A1.2:

1. Product  $A_n$  is a product to be qualified that belongs to Product Family A.
2. Product  $A_1$  should be representative of the product family, possibly a more complex case family part (e.g., 60V regulator vs. 45V regulator, 8 channel vs. 4 channel amplifier) that would cover most, if not all, other family parts.
3. Same Fab is same process node and materials. Different Fab has one or more different process elements.
4. Same Assembly is same process, materials and package type. Different Assembly has one or more different process, material elements or package elements.
5. New test is qualification tests per Section 4.1
6. Fab process  $C_1$  is the same as C except for one or more different elements (e.g., Al to Cu metal).
7. Assembly process  $E_1$  is the same as E except for one or more different elements (e.g. Al to Cu bond wire, mold compound).
8. Product B is functionally different from Product A (e.g., logic vs. analog, voltage regulator vs. amplifier).
9. Increased product complexity can decrease the applicability for portion of the table below.

**New Qualification Scenario (Definition of Part to be Qualified)**

<u>Case</u>	<u>Description</u>	<u>Product</u>	<u>Fab Site</u>	<u>Assembly Site</u>	<u>Min. Lots of Data Needed for Qualification</u>	<u>Product/Process (defined in Appendix A1)</u>
<u>New Device / Product</u>	<u>This is the unqualified device / product</u>	<u><math>A_n</math></u>	<u>C</u>	<u>E</u>	<u>3</u>	<ul style="list-style-type: none"> <li>• <u>1 lot ESD and LU; 3 lots ED AC(E) and 1 lot HTOL minimum on <math>A_n</math>CE in addition to below for all cases</u></li> </ul>

**Previously Qualified Scenario (Existing Generic Data)**

<u>Case</u>	<u>Description</u>	<u>Product</u>	<u>Fab Site</u>	<u>Assembly Site</u>	<u>Lots of Generic Data Available</u>	<u>Use Options of Generic Data</u>
<u>1</u>	<u>B from a different product family</u>	<u>B</u>	<u>C</u>	<u>E</u>	<u>3</u>	<p><b><u>No Option</u></b></p> <ul style="list-style-type: none"> <li>• <u>3 lots <math>A_n</math>CE (new test)</u></li> </ul>
<u>2A</u>	<u>B from a different product family</u>	<u>B</u>	<u>C</u>	<u>F</u>	<u>3</u>	<p><b><u>No Option</u></b></p> <ul style="list-style-type: none"> <li>• <u>3 lots using <math>A_n</math> (new test)</u></li> </ul>
<u>2B</u>			<u>D</u>	<u>E</u>	<u>3</u>	<p><b><u>No Option</u></b></p> <ul style="list-style-type: none"> <li>• <u>3 lots <math>A_n</math>CE (new test)</u></li> </ul>
<u>3</u>	<u>Different Fab Process and different site as <math>A_1</math></u> <u>Different Assembly and different site as <math>A_1</math></u>	<u><math>A_1</math></u>	<u>D</u>	<u>F</u>	<u>3</u>	<p><b><u>No Option</u></b></p> <ul style="list-style-type: none"> <li>• <u>3 lots using <math>A_n</math> (new test)</u></li> </ul>

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**Table A1.2: Examples for Generic Data Use (Continued)**

**Previously Qualified Scenario (Existing Generic Data) (continued)**

<u>Case</u>	<u>Description</u>	<u>Product</u>	<u>Fab Site</u>	<u>Assembly Site</u>	<u>Lots of Generic Data Available</u>	<u>Use Options of Generic Data</u>
<u>4A</u>	One or more elements of the fab process is different than the base process  Same Assembly Process and site as <u>A<sub>1</sub></u>	<u>A<sub>1</sub></u>	<u>C<sub>1</sub></u>	<u>E</u>	<u>3</u>	<ul style="list-style-type: none"> <li>• <u>3 lots A<sub>n</sub>CE (new test)</u> <b>OR</b></li> <li>• <u>2 lots A<sub>n</sub>CE (new test) + 2 lots A<sub>1</sub>C<sub>1</sub>E (generic)</u> <b>OR</b></li> <li>• <u>1 lot A<sub>n</sub>CE (new test) + 3 lots A<sub>1</sub>C<sub>1</sub>E (generic)</u></li> </ul>
<u>4B</u>	Same Fab Process and same site as <u>A<sub>1</sub></u>  One or more elements of the assembly process is different than the base process <u>E</u>		<u>C</u>	<u>E<sub>1</sub></u>	<u>3</u>	<ul style="list-style-type: none"> <li>• <u>3 lots A<sub>n</sub>CE (new test)</u> <b>OR</b></li> <li>• <u>2 lots A<sub>1</sub>CE (new test) + 2 lots A<sub>1</sub>CE<sub>1</sub> (generic)</u> <b>OR</b></li> <li>• <u>1 lot A<sub>1</sub>CE (new test) + 3 lots A<sub>1</sub>CE<sub>1</sub> (generic)</u></li> </ul>
<u>5A</u>	Same Fab Process and site as <u>A<sub>n</sub></u>  Same Assembly Process but different site as <u>A<sub>n</sub></u>	<u>A<sub>1</sub></u>	<u>C</u>	<u>F</u>	<u>3</u>	<ul style="list-style-type: none"> <li>• <u>3 lots A<sub>n</sub>CE (new test)</u> <b>OR</b></li> <li>• <u>2 lots A<sub>n</sub>CE (new test) + 2 lots A<sub>1</sub>CF (generic)</u> <b>OR</b></li> <li>• <u>1 lot A<sub>n</sub>CE (new test) + 3 lots A<sub>1</sub>CF (generic)</u></li> </ul>
<u>5B</u>	Same Fab Process, but different site as <u>A<sub>n</sub></u>  Same Assembly Process and site as <u>A<sub>n</sub></u>		<u>D</u>	<u>E</u>	<u>3</u>	<ul style="list-style-type: none"> <li>• <u>3 lots A<sub>n</sub>CE (new test)</u> <b>OR</b></li> <li>• <u>2 lots A<sub>n</sub>CE (new test) + 2 lots A<sub>1</sub>DE (generic)</u> <b>OR</b></li> <li>• <u>1 lot A<sub>n</sub>CE (new test) + 3 lots A<sub>1</sub>DE (generic)</u></li> </ul>
<u>6</u>	Same Fab Process and site as <u>A<sub>n</sub></u>  Same Assembly Process and site as <u>A<sub>n</sub></u>	<u>A<sub>1</sub></u>	<u>C</u>	<u>E</u>	<u>3</u>	<ul style="list-style-type: none"> <li>• <u>3 lots A<sub>1</sub>CE (Generic)</u></li> </ul>

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**A1.5 Qualification of Changes in Multiple Sites and Families**

**A1.5.1 Multiple Sites**

When the specific product or process attribute to be qualified or requalified will affect more than one wafer fab site or assembly site, a minimum of one lot of testing per affected site is required.

**A1.5.2 Multiple Families**

When the specific product or process attribute to be qualified or requalified will affect more than one wafer fab family or assembly family, the qualification test vehicles should be: 1) One lot of a single device type from each of the families that are projected to be most sensitive to the changed attribute, or 2) Three lots total (from any combination of acceptable generic data and stress test data) from the most sensitive families if only one or two families exist.

Below is the recommended process for qualifying changes across many process and product families:

- a. Identify all products affected by the proposed process changes.
- b. Identify the critical structures and interfaces potentially affected by the proposed process change.
- c. Identify and list the potential failure mechanisms and associated failure modes for the critical structures and interfaces (see the example in Table A1.3). Note that steps (a) to (c) are equivalent to the creation of an FMEA.
- d. Define the product groupings or families based upon similar characteristics as they relate to the structures and device sensitivities to be evaluated, and provide technical justification to document the rationale for these groupings.
- e. Provide the qualification test plan, including a description of the change, the matrix of tests, and the representative products, that will address each of the potential failure mechanisms and associated failure modes.
- f. Robust process capability must be demonstrated at each site (e.g., control of each process step, capability of each piece of equipment involved in the process, equivalence of the process step-by-step across all affected sites) for each of the affected process steps.

**Table A1.3: Example of Failure Mode/Mechanism List for a Passivation Change**

<b>Critical Structure or Interface</b>	<b>Potential Failure Mechanism</b>	<b>Associated Failure Modes</b>	<b>On These Products</b>
Passivation to Mold Compound Interface	Passivation Cracking - Corrosion	Functional Failures	All Die
	Mold Compound - Passivation Delamination	Corner Wire Bond Failures	Large Die
Passivation to Metallization Interface	Stress-Induced Voiding	Functional Failures	Die with Minimum Width Metal Lines
	Ionic Contamination	Leakage, Parametric Shifts	All Die
Polysilicon and Active Resistors	Piezoelectric Leakage	Parametric Shifts (e.g., Resistance, Gain, Offset)	Analog Products

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**Appendix 2: Q100 Certification of Design, Construction and Qualification**

**Supplier Name:**

**Date:**

The following information is required to identify a device that has met the requirements of AEC-Q100. Submission of the required data in the format shown below is optional. **All entries must be completed; if a particular item does not apply, enter "Not Applicable".** This template can be downloaded from the AEC website at <http://www.aecouncil.com>.

**This template is available as a stand-alone document.**

Item Name	Supplier Response
1. User's Part Number:	
2. Supplier's Part Number/Data Sheet:	
3. Device Description:	
4. Wafer/Die Fab Location & Process ID: a. Facility name/plant #: b. Street address: c. Country:	
5. Wafer Probe Location: a. Facility name/plant #: b. Street address: c. Country:	
6. Assembly Location & Process ID: a. Facility name/plant #: b. Street address: c. Country:	
7. Final Quality Control A (Test) Location: a. Facility name/plant #: b. Street address: c. Country:	
8. Wafer/Die: a. Wafer size: b. Die family: c. Die mask set revision & name: d. Die photo:	See attached <input type="checkbox"/> Not available <input type="checkbox"/>
9. Wafer/Die Technology Description: a. Wafer/Die process technology: b. Die channel length: c. Die gate length: d. Die supplier process ID (Mask #): e. Number of transistors or gates: f. Number of mask steps:	
10. Die Dimensions: a. Die width: b. Die length: c. Die thickness (finished):	
11. Die Metallization: a. Die metallization material(s): b. Number of layers: c. Thickness (per layer): d. % of alloys (if present):	

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<p>12. Die Passivation:  a. Number of passivation layers:  b. Die passivation material(s):  c. Thickness(es) &amp; tolerances:</p>	
<p>13. Die Overcoat Material (e.g., Polyimide):</p>	
<p>14. Die Cross-Section Photo/Drawing:</p>	<p>See attached <input type="checkbox"/> Not available <input type="checkbox"/></p>
<p>15. Die Prep Backside:  a. Die prep method:  b. Die metallization:  c. Thickness(es) &amp; tolerances:</p>	
<p>16. Die Separation Method:  a. Kerf width (<math>\mu\text{m}</math>):  b. Kerf depth (if not 100% saw):  c. Saw method:</p>	<p>Single <input type="checkbox"/> Dual <input type="checkbox"/></p>
<p>17. Die Attach:  a. Die attach material ID:  b. Die attach method:  c. Die placement diagram:</p>	<p>See attached <input type="checkbox"/> Not available <input type="checkbox"/></p>
<p>18. Package:  a. Type of package (e.g., plastic, ceramic, unpackaged):  b. Ball/lead count:  c. JEDEC designation (e.g., MS029, MS034):  d. Lead (Pb) free (&lt; 0.1% homogenous material):  e. Package outline drawing:</p>	<p>Yes <input type="checkbox"/> No <input type="checkbox"/>  See attached <input type="checkbox"/> Not available <input type="checkbox"/></p>
<p>19. Mold Compound:  a. Mold compound supplier &amp; ID:  b. Mold compound type:  c. Flammability rating:  d. Fire Retardant type/composition:  e. Tg (glass transition temperature)(<math>^{\circ}\text{C}</math>):  f. CTE (above &amp; below Tg)(ppm/<math>^{\circ}\text{C}</math>):</p>	<p>UL 94 V1 <input type="checkbox"/> UL 94 V0 <input type="checkbox"/>  CTE1 (above Tg) = _____ CTE2 (below Tg) = _____</p>
<p>20. Wire Bond:  a. Wire bond material:  b. Wire bond diameter (mils):  c. Type of wire bond at die:  d. Type of wire bond at leadframe:  e. Wire bonding diagram:</p>	<p>See attached <input type="checkbox"/> Not available <input type="checkbox"/></p>
<p>21. Leadframe (if applicable):  a. Paddle/flag material:  b. Paddle/flag width (mils):  c. Paddle/flag length (mils):  d. Paddle/flag plating composition:  e. Paddle/flag plating thickness (<math>\mu\text{inch}</math>):  f. Leadframe material:  g. Leadframe bonding plating composition:  h. Leadframe bonding plating thickness (<math>\mu\text{inch}</math>):  i. External lead plating composition:  j. External lead plating thickness (<math>\mu\text{inch}</math>):</p>	



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<p>22. Substrate (if applicable):</p> <ul style="list-style-type: none"> <li>a. Substrate material (e.g., FR5, BT):</li> <li>b. Substrate thickness (mm):</li> <li>c. Number of substrate metal layers:</li> <li>d. Plating composition of ball solderable surface:</li> <li>e. Panel singulation method:</li> <li>f. Solder ball composition:</li> <li>g. Solder ball diameter (mils):</li> </ul>	
<p>23. Unpackaged Die (if not packaged):</p> <ul style="list-style-type: none"> <li>a. Under Bump Metallurgy (UBM) composition:</li> <li>b. Thickness of UBM metal:</li> <li>c. Bump composition:</li> <li>d. Bump size:</li> </ul>	
<p>24. Header Material (if applicable):</p>	
<p>25. Thermal Resistance:</p> <ul style="list-style-type: none"> <li>a. <math>\theta_{JA}</math> °C/W (approx):</li> <li>b. <math>\theta_{JC}</math> °C/W (approx):</li> <li>c. Special thermal dissipation construction techniques:</li> </ul>	
<p>26. Test circuits, bias levels, &amp; operational conditions imposed during the supplier's life and environmental tests:</p>	<p>See attached <input type="checkbox"/> Not available <input type="checkbox"/></p>
<p>27. Fault Grade Coverage (%)</p>	<p>_____ % Not digital circuitry <input type="checkbox"/></p>
<p>28. Maximum Process Exposure Conditions:</p> <ul style="list-style-type: none"> <li>a. MSL @ rated SnPb temperature:</li> <li>b. MSL @ rated Pb-free temperature:</li> <li>c. Maximum dwell time @ maximum process temperature:</li> </ul>	<p><i>* Note: Temperatures are as measured on the center of the plastic package body top surface.</i></p> <p>_____ at _____ °C (SnPb) _____ at _____ °C (Pb-free)</p>
<p>Attachments:</p> <ul style="list-style-type: none"> <li>Die Photo <input type="checkbox"/></li> <li>Package Outline Drawing <input type="checkbox"/></li> <li>Die Cross-Section Photo/Drawing <input type="checkbox"/></li> <li>Wire Bonding Diagram <input type="checkbox"/></li> <li>Die Placement Diagram <input type="checkbox"/></li> <li>Test Circuits, Bias Levels, &amp; Conditions <input type="checkbox"/></li> </ul>	<p>Requirements:</p> <ol style="list-style-type: none"> <li>1. A separate Certification of Design, Construction &amp; Qualification must be submitted for each P/N, wafer fab, and assembly location.</li> <li>2. Design, Construction &amp; Qualification shall be signed by the responsible individual at the supplier who can verify the above information is accurate and complete. Type name and sign below.</li> </ol>
<p>Completed by: _____ Date: _____</p>	<p>Certified by: _____ Date: _____</p>
<p>Typed or Printed:</p> <p>Signature: _____</p> <p>Title: _____</p>	

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## **Appendix 3: Plastic Package Opening for Wire Bond Testing**

### **A3.1 Purpose**

The purpose of this Appendix is to define a guideline for opening plastic packaged devices so that reliable wire pull or bond shear results will be obtained. This method is intended for use in opening plastic packaged devices to perform wire pull testing after temperature cycle testing or for bond shear testing.

### **A3.2 Materials and Equipment**

#### **A3.2.1 Etchants**

Various chemical strippers and acids may be used to open the package dependent on your experience with these materials in removing plastic molding compounds. Red Fuming Nitric Acid has demonstrated that it can perform this function very well on novolac type epoxies, but other materials may be utilized if they have shown a low probability for damaging the bond pad material.

#### **A3.2.2 Plasma Strippers**

Various suitable plasma stripping equipment can be utilized to remove the plastic package material.

### **A3.3 Procedure**

- a. Using a suitable end mill type tool or dental drill, create a small impression just a little larger than the chip in the top of the plastic package. The depth of the impression should be as deep as practical without damaging the loop in the bond wires.
- b. Using a suitable chemical etchant or plasma etcher, remove the plastic material from the surface of the die, exposing the die bond pad, the loop in the bond wire, and at least 75% of the bond wire length. Do not expose the wire bond at the lead frame (these bonds are frequently made to a silver plated area and many chemical etchants will quickly degrade this bond making wire pull testing impossible).
- c. Using suitable magnification, inspect the bond pad areas on the chip to determine if the package removal process has significantly attacked the bond pad metallization. If a bond pad shows areas of missing metallization, the pad has been degraded and shall not be used for bond shear or wire pull testing. Bond pads that do not show attack can be used for wire bond testing.

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**Appendix 4: Minimum Requirements for Qualification Plans and Results**

The following information is required as a minimum to identify a device that has met the requirements of AEC-Q100 (see Appendix Templates 4A and 4B). Submission of data in this format is optional. However, if these templates are not used, the supplier must ensure that each item on the template is adequately addressed. The templates can be downloaded from the AEC website at <http://www.aecouncil.com>.

**A4.1 Plans**

1. Part Identification: Customer P/N and supplier P/N.
2. Site or sites at which life testing will be conducted.
3. List of tests to be performed (e.g., JEDEC method, Q100 method, MIL-STD method) along with conditions. Include specific temperature(s), humidity, and bias to be used.
4. Sample size and number of lots required.
5. Time intervals for end-points (e.g., 0 hour, 500 hour, 1000 hour).
6. Targeted start and finish dates for all tests and end-points.
7. Supplier name and contact.
8. Submission date.
9. Material and functional details and test results of devices to be used as generic data for qualification. Include rationale for use of generic data.

**A4.2 Results**

All of above plus:

1. Date codes and lot codes of parts tested.
2. Process identification.
3. Fab and assembly locations.
4. Mask number or designation.
5. Number of failures and number of devices tested for each test.
6. Failure analyses for all failures and corrective action reports to be submitted with results.

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**Appendix Template 4A: AEC-Q100 Qualification Test Plan**

Q100H QUALIFICATION TEST PLAN							
USER COMPANY:				DATE:			
USER P/N:			TRACKING NUMBER:				
USER SPEC #:			USER COMPONENT ENGINEER:				
SUPPLIER COMPANY:			SUPPLIER MANUFACTURING SITES:				
SUPPLIER P/N:			PPAP SUBMISSION DATE:				
SUPPLIER FAMILY TYPE:			REASON FOR QUALIFICATION:				
STRESS TEST	ABV	TEST#	TEST METHOD	Test Conditions/S.S. per Lot/# Lots (identify temp, RH, & bias)	REQUIREMENTS		RESULTS Fails/S.S./# lots
					S.S	# LOTS	
Preconditioning	PC	A1	JEDEC J-STD-020	Peak Reflow Temp. = Preconditioning used =	Min. MSL = 3		MSL =
Temperature Humidity Bias or HAST	THB / HAST	A2	JESD22-A101/A110		77	3	
Autoclave or Unbiased HAST	AC / UHST	A3	JESD22-A102/A118		77	3	
Temperature Cycle	TC	A4	JESD22-A104		77	3	
Power Temperature Cycling	PTC	A5	JESD22-A105		45	1	
High Temperature Storage Life	HTSL	A6	JESD22-A103		45	1	
High Temperature Operating Life	HTOL	B1	JESD22-A108		77	3	
Early Life Failure Rate	ELFR	B2	AEC Q100-008		800	3	
NVM Endurance, Data Retention, & Operational Life	EDR	B3	AEC Q100-005		77	3	
Wire Bond Shear	WBS	C1	AEC Q100-001		5	1	
Wire Bond Pull Strength	WBP	C2	MIL-STD-883 - 2011		5	1	
Solderability	SD	C3	JESD22-B102 J-STD-002D	8 hr steam aging prior to testing	15	1	
Physical Dimensions	PD	C4	JESD22-B100/B108		10	3	
Solder Ball Shear	SBS	C5	AEC Q100-010		10	3	
Lead Integrity	LI	C6	JESD22-B105		5	1	
Electromigration	EM	D1					
Time Dependent Dielectric Breakdown	TDDDB	D2					
Hot Carrier Injection	HCI	D3					
Negative Bias Temperature Instability	NBTI	D4					
Stress Migration	SM	D5					
Pre- and Post-Stress Electrical Test	TEST	E1	Test to spec				
ESD - Human Body Model	HBM	E2	AEC Q100-002		See Test Method		
ESD - Charged Device Model	CDM	E3	AEC Q100-011		See Test Method		
Latch-Up	LU	E4	AEC Q100-004		6	1	
Electrical Distributions	ED	E5	AEC Q100-009		30	3	
Fault Grading	FG	E6	AEC-Q100-007				
Characterization	CHAR	E7	AEC Q003				
Electromagnetic Compatibility	EMC	E9	SAE J1752/3		1	1	
Short Circuit Characterization	SC	E10	AEC Q100-012		10	3	
Soft Error Rate	SER	E11	JESD89-1, -2, -3		3	1	
Lead Free	LF	E12	Q005				
Process Average Test	PAT	F1	AEC Q001				
Statistical Bin/Yield Analysis	SBA	F2	AEC Q002				
Hermetic Package Tests	MECH	G1-4	Series		15	1	
Package Drop	DROP	G5			5	1	
Lid Torque	LT	G6	MIL-STD-883 - 2024		5	1	
Die Shear Strength	DS	G7	MIL-STD-883 - 2019		5	1	
Internal Water Vapor	IWV	G8	MIL-STD-883 - 1018		5	1	
Supplier:				Approved by: (User Engineer)			

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**Appendix Template 4B: AEC-Q100 Generic Data**

Objective: \_\_\_\_\_  
 Device: \_\_\_\_\_  
 Cust PN: \_\_\_\_\_  
 Maskset: \_\_\_\_\_  
 Die Size: \_\_\_\_\_

Package: \_\_\_\_\_  
 Fab/Assy/Test: \_\_\_\_\_  
 Device Engr: \_\_\_\_\_  
 Product Engr: \_\_\_\_\_  
 Component Engr: \_\_\_\_\_

Qual Plan Ref #: \_\_\_\_\_  
 Date Prepared: \_\_\_\_\_  
 Prepared by: \_\_\_\_\_  
 Date Approved: \_\_\_\_\_  
 Approved by: \_\_\_\_\_

Test #	ABV	Q100 Test Conditions	End-Point Requirements	Sample Size/Lot	# of Lots	Total # Units	Part to be Qualified	Differences from Q100	Generic Family part A	Differences from Q100	Generic Family part B	Differences from Q100
A1	PC	JEDEC J-STD-020	TEST = ROOM	All surface mount parts prior to A2, A3, A4, A5								
A2	THB / HAST	JESD22-A101/A110	TEST = ROOM and HOT	77	3	231						
A3	AC / UHST	JESD22-A102/A118	TEST = ROOM	77	3	231						
A4	TC	JESD22-A104	TEST = HOT	77	3	231						
A5	PTC	JESD22-A105	TEST = ROOM and HOT	45	1							
A6	HTSL	JESD22-A103	TEST = ROOM and HOT	45	1							
B1	HTOL	JESD22-A108	TEST = ROOM, COLD, and HOT	77	3	231						
B2	ELFR	AEC Q100-008	TEST = ROOM and HOT	800	3	2400						
B3	EDR	AEC Q100-005	TEST = ROOM and HOT	77	3	231						
C1	WBS	AEC Q100-001	Cpk>1.5 and in SPC	An appropriate time period for each bonder to be used								
C2	WBP	MIL-STD-883 – 2011										
C3	SD	JESD22-B102 J-STD-002D	>95% solder coverage	15	1	15						
C4	PD	JESD22-B100/B108	Cpk > 1.5 per JESD95	10	3	30						
C5	SBS	AEC Q100-010	Two 220°C reflow cycles before SBS									
C6	LI	JESD22-B105	No lead breakage or finish cracks	10 leads from each of 5	1	5						
D1	EM											
D2	Tddb											
D3	HCI											
D4	NBTI											
D5	SM											
E1	TEST		All parametric and functional tests	All units	-	All						
E2	HBM	AEC Q100-002	TEST = ROOM and HOT		1	Var.						
E3	CDM	AEC Q100-011	TEST = ROOM and HOT		1	Var.						
E4	LU	AEC Q100-004	TEST = ROOM and HOT	6	1	6						
E5	ED	AEC Q100-009	TEST = ROOM, HOT, and COLD	30	3	90						
E6	FG	AEC Q100-007										
E7	CHAR	AEC Q003										
E9	EMC	SAE J1752/3		1	1	1						
E10	SC	AEC Q100-012		10	3	30						
E11	SER	JESD89-1, -2, -3		3	1	3						
E12	LF	Q005										
F1	PAT	AEC Q001		All units	-	All						
F2	SBA	AEC Q002		All units	-	All						
G1	MS	JESD22-B104	TEST = ROOM	15	1	15						
G2	VFV	JESD22-B103	TEST = ROOM	15	1	15						
G3	CA	MIL-STD-883 – 2001	TEST = ROOM	15	1	15						
G4	GFL	MIL-STD-883 – 1014		15	1	15						
G5	DROP		TEST = ROOM	5	1	5						
G6	LT	MIL-STD-883 – 2024		5	1	5						
G7	DS	MIL-STD-883 – 2019		5	1	5						
G8	IWV	MIL-STD-883 - 1018		5	1	3						

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**Appendix Template 4B: AEC-Q100 Generic Data (continued)**

Part Attributes	Part to be Qualified	Generic Family Part A	Generic Family Part B
User Part Number			
Supplier Part Number			
<u>A1.1 Product</u>			
<u>Product Functionality (e.g., Op-Amp, Regulator, Microprocessor, Logic – HC/TTL)</u>			
<u>Operating Supply Voltage Range(s)</u>			
<u>Specified Operating Temperature Range</u>			
<u>Specified Operating Frequency Range</u>			
<u><sup>1</sup> Analog Design Library Cells (e.g., active circuit elements, passive circuit elements)</u>			
<u><sup>1</sup> Digital Design Library Cells (e.g., circuit blocks, IO modules, ESD cells)</u>			
<u>Memory IP (e.g., cell structure, building block)</u>			
<u>Memory Type(s) &amp; Size(s)</u>			
<u>Design Rules for Active Circuits under Pads</u>			
<u>Other Functional Characteristics (as defined by supplier)</u>			
<u>A1.2 Fab Process</u>			
<u>Wafer Fab Technology (e.g., CMOS, NMOS, Bipolar)</u>			
<u>Circuit Element Feature Size (e.g., layout design rules, die shrinks, contacts, gates, isolations)</u>			
<u>Substrate (e.g., orientation, doping, epi, wafer size)</u>			
<u>Maximum Number of Masks (supplier must show justification for waiving this requirement)</u>			
<u>Lithographic Process (e.g., contact vs. projection, E-beam vs. X-ray, photoresist polarity)</u>			
<u>Doping Process (e.g., diffusion vs. ion implantation)</u>			
<u>Gate Structure, Material &amp; Process (e.g., polysilicon, metal, salicide, wet vs. dry etch)</u>			
<u>Polysilicon Material, Thickness Range, &amp; Number of Levels</u>			
<u>Oxidation Process &amp; Thickness Range (e.g., gate &amp; field oxides)</u>			
<u>Interlevel Dielectric Material &amp; Thickness Range</u>			
<u>Metallization Material, Thickness Range, &amp; Maximum Number of Levels</u>			
<u>Passivation Process (e.g., passivation oxide opening), Material, &amp; Thickness Range</u>			
<u>Die Backside Preparation Process &amp; Metallization</u>			
<u>Wafer Fabrication Site</u>			

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**Appendix Template 4B: AEC-Q100 Generic Data (continued)**

Part Attributes	Part to be Qualified	Generic Family Part A	Generic Family Part B
<u>A1.3 Assembly Process – Plastic or Ceramic</u>			
Assembly Site			
Package Type (e.g., DIP, SOIC, QFP, PGA, PBGA)			
Range of Paddle/Flag Size (maximum & minimum dimensions) Qualified for the Die Size/Aspect Ratio Under Consideration			
Worst Case Package (e.g., package warpage due to CTE mismatch)			
Substrate Base Material (e.g., PBGA)			
Leadframe Base Material			
Die Header / Thermal Pad Material			
Leadframe Plating Material & Process (internal & external to the package)			
Die Attach Material			
Wire Bond Material & Diameter			
Wire Bond Method, Presence of Downbonds, & Process			
Plastic Mold Compound Material, Organic Substrate Material, or Ceramic Package Material			
Plastic Mold Compound Supplier/ID			
Solder Ball Metallization System (if applicable)			
Heatsink Type, Material, & Dimensions			
Die Preparation/Singulation			

Note 1: Design Library cells need to follow guidelines for temperature ranges, voltage ranges, speed, performance, and power dissipation as defined in Appendix 1.

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### **Appendix 5: Part Design Criteria to Determine Need for EMC Testing**

- A5.1 Use the following criteria to determine if a part is a candidate for EMC testing:
- a. Digital technology, LSI, products with oscillators or any technology that has the potential of producing radiated emissions capable of interfering with communication receiver devices. Examples include microprocessors, high speed digital IC's, FET's incorporating charge pumps, devices with watchdogs, and switch-mode regulator control and driver IC's.
  - b. All new, requalified, or existing IC's that have undergone revisions from previous versions that have the potential of producing radiated emissions capable of interfering with communication receiver devices.
- A5.2 Examples of factors that would be expected to affect radiated emissions:
- Clock drive (internal or external) I/O Drive
  - Manufacturing process or material composition that reduces rise/fall times (e.g., lower E dielectric, lower p metallization)
  - Minimum feature size (e.g., die shrink)
  - Package or pinout configuration
  - Leadframe material



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### **Appendix 6: Part Design Criteria to Determine Need for SER Testing**

- A6.1 Use the following criteria to determine if a part is a candidate for SER Testing:
- a. The part use application will have a significant radiation exposure such as an aviation application or extended service life at higher altitudes.
  - b. SER testing is needed for devices with large numbers of SRAM or DRAM cells ( $\geq 1$  Mbit). For example: Since the SER rates for a 130 nm technology are typically near 1000 FIT/MBIT, a device with only 1,000 SRAM cells will result in an SER contribution of  $\sim 1$  FIT.
- A6.2 Examples of factors that would be expected to affect SER results:
- a. Technology shrink to small  $L_{\text{effective}}$ .
  - b. Package mold/encapsulate material.
  - c. Bump material making die to package connections for Flip Chip package applications.
  - d. Mitigating factors such as implementation of Error Correcting Code (ECC) and Soft Error Detection (SED).
- A6.3 Cases where new SER testing may be required:
- a. Change in basic SRAM/DRAM transistor cell structure (e.g.,  $L_{\text{eff}}$ , well depth and dopant concentration, isolation method).

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## Appendix 7: AEC-Q100 AND THE USE OF MISSION PROFILES

### A7.1 SCOPE

Successful completion of the test requirements in Table 2 allows the claim to be made that the part is AEC Q100 qualified. Additional testing may be agreed between Component Manufacturers and Tier 1 Component Users depending on more demanding application environments. To address these more stringent conditions, application based Mission Profiles may be used for a reliability capability.

A mission profile is the collection of relevant environmental and functional loads that a component will be exposed to during its use lifetime.

#### A7.1.1 Purpose

This appendix provides information on an approach that can be used to assess the suitability of a component for a given application and its mission profile for unique requirements. The benefit of applying this approach is that, in the end, the reliability margin between the component (specification) space and the application (condition) space may be shown.

- Section A7.2 demonstrates the relation between AEC-Q100 stress conditions / durations and a typical example of a set of use life time and loading conditions.
- Section A7.3 describes the approach, supported by flow charts, which can be used for a reliability capability assessment starting from a mission profile description.

#### A7.1.2 References

- SAE J1879/J1211/ZVEI Handbook for Robustness Validation of Semiconductor Devices in Automotive Applications
- JEDEC JEP122 Failure Mechanisms and Models for Semiconductor Devices

### A7.2 BASE CONSIDERATIONSE

#### A7.2.1 Use Lifetime and Mission Profile

The use lifetime assumptions drawn here are an example used for demonstration purpose only. Many typical mission profiles will differ in one or more characteristics from what is shown below.

- service lifetime in years
- engine on-time in hours
- engine off time { idle} in hours
- non-operating time in hours
- number of engine on-off cycles
- service mileage

The mission profile itself is generated by adding information on thermal, electrical, mechanical and any other forms of loading under use conditions to the above lifetime characteristics. Examples of these and how they relate to the test conditions in Table 2 are shown in Table A7.1.

#### A7.2.2 Relation to AEC-Q100 Stress Test Conditions and Durations

The basic calculations in Table A7.1 for each of the major stress tests demonstrate how one can derive suitable test conditions for lifetime characteristics based on reasonable assumptions for the loading. Caution should always be taken on use of excessive test conditions beyond those in Table 2, because they may induce unrealistic fail mechanisms and/ or acceleration.

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#### **A7.3 METHOD TO ASSESS A MISSION PROFILE**

This section demonstrates how to perform a more detailed reliability capability assessment in cases where the application differs significantly from existing and proven situations:

- Application has a demanding loading profile
- Application has an extended service lifetime requirement
- Application has a more stringent failure rate target over lifetime

These considerations may result in extended test durations. In addition, there may be components manufactured in new technologies and/or containing new materials that are not yet qualified. In such cases, unknown failure mechanisms may occur with different times-to-failure which may require different test methods and/or conditions and/or durations.

For these cases, two flow charts are available to facilitate both Tier 1 and Component Manufacturing in a reliability capability assessment:

- Flow Chart 1 in Figure A7.1 describes the process at Component Manufacturer to assess whether a new component can be qualified by AEC-Q100.
- Flow Chart 2 in Figure A7.2 describes (1) the process at Tier 1 to assess whether a certain electronic component fulfills the requirements of the mission profile of a new Electronic Control Unit (ECU); and (2) the process at Component Manufacturer to assess whether an existing component qualified according to AEC-Q100 can be used in a new application.

For details on how to apply this method, please refer to SAE J1879, SAE J1211, and/or ZVEI Handbook for Robustness Validation of Semiconductor Devices in Automotive Applications.

In summary, the flow charts result in the following three clear possible conclusions:

- [A] AEC-Q100 test conditions do apply.
- [B] Mission Profile specific test conditions may apply.
- [C] Robustness Validation may be applied with detailed alignment between Tier1 and Component Manufacturer.

In addition, not shown in the flow charts, the expected end of life failure rate may be an important criterion. Regarding failure rates, the following points should be considered:

- No fails in 231 devices (77 devices from 3 lots) are applied as pass criteria for the major environmental stress tests. This represents an LTPD (Lot Tolerance Percent Defective) = 1, meaning a maximum of 1% failures at 90% confidence level.
- This sample size is sufficient to identify intrinsic design, construction, and/or material issues affecting performance.
- This sample size is NOT sufficient or intended for process control or PPM evaluation. Manufacturing variation failures (low ppm issues) are achieved through proper process controls and/or screens such as described in AEC-Q001 and AEC-Q002.
- Three lots are used as a minimal assurance of some process variation between lots. A monitoring process has to be installed to keep process variations under control.
- Sample sizes are limited by part and test facility costs, qualification test duration and limitations in batch size per test.

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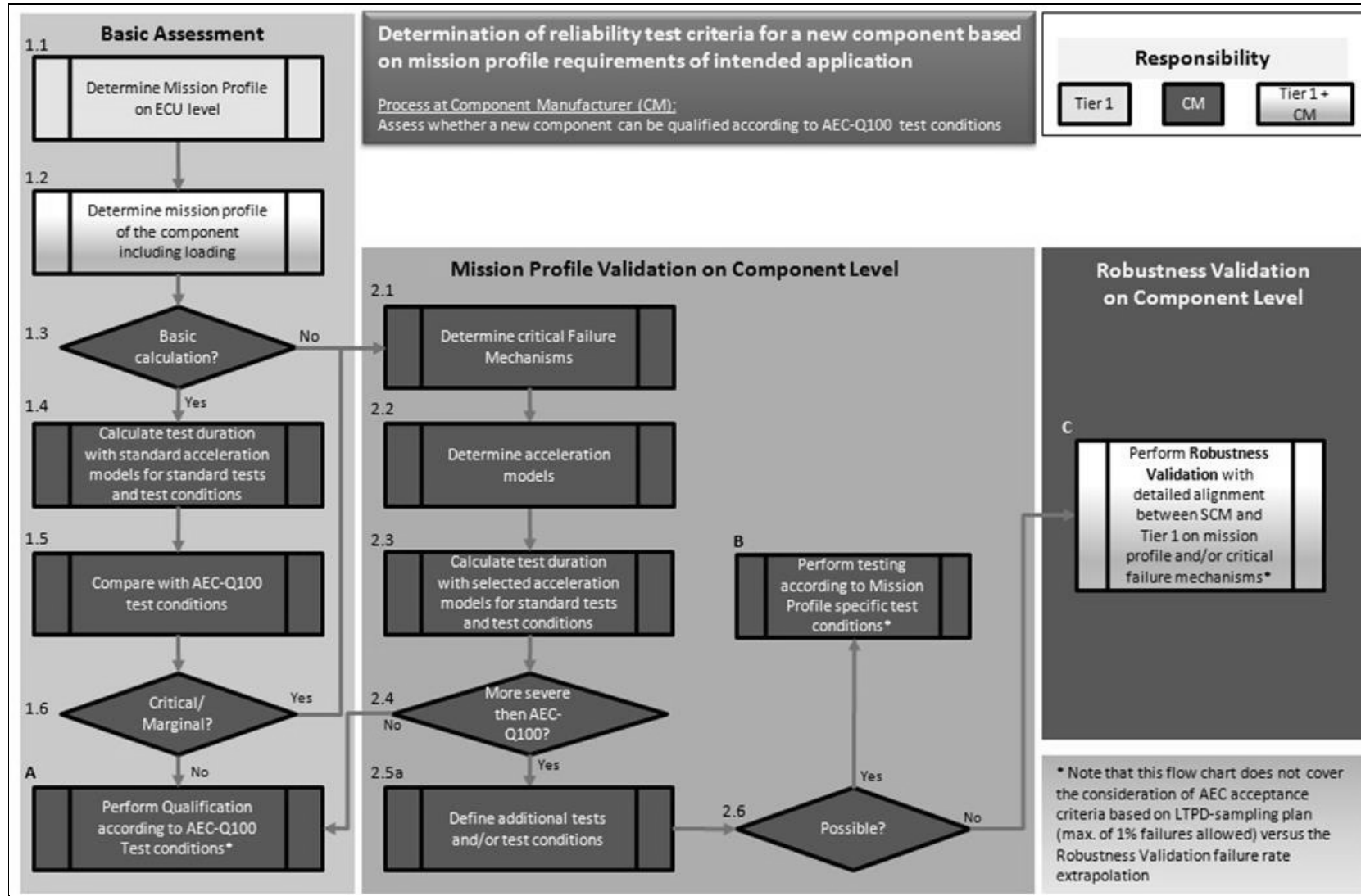


Figure A7.1: Flow Chart 1 – Reliability Test Criteria for New Component

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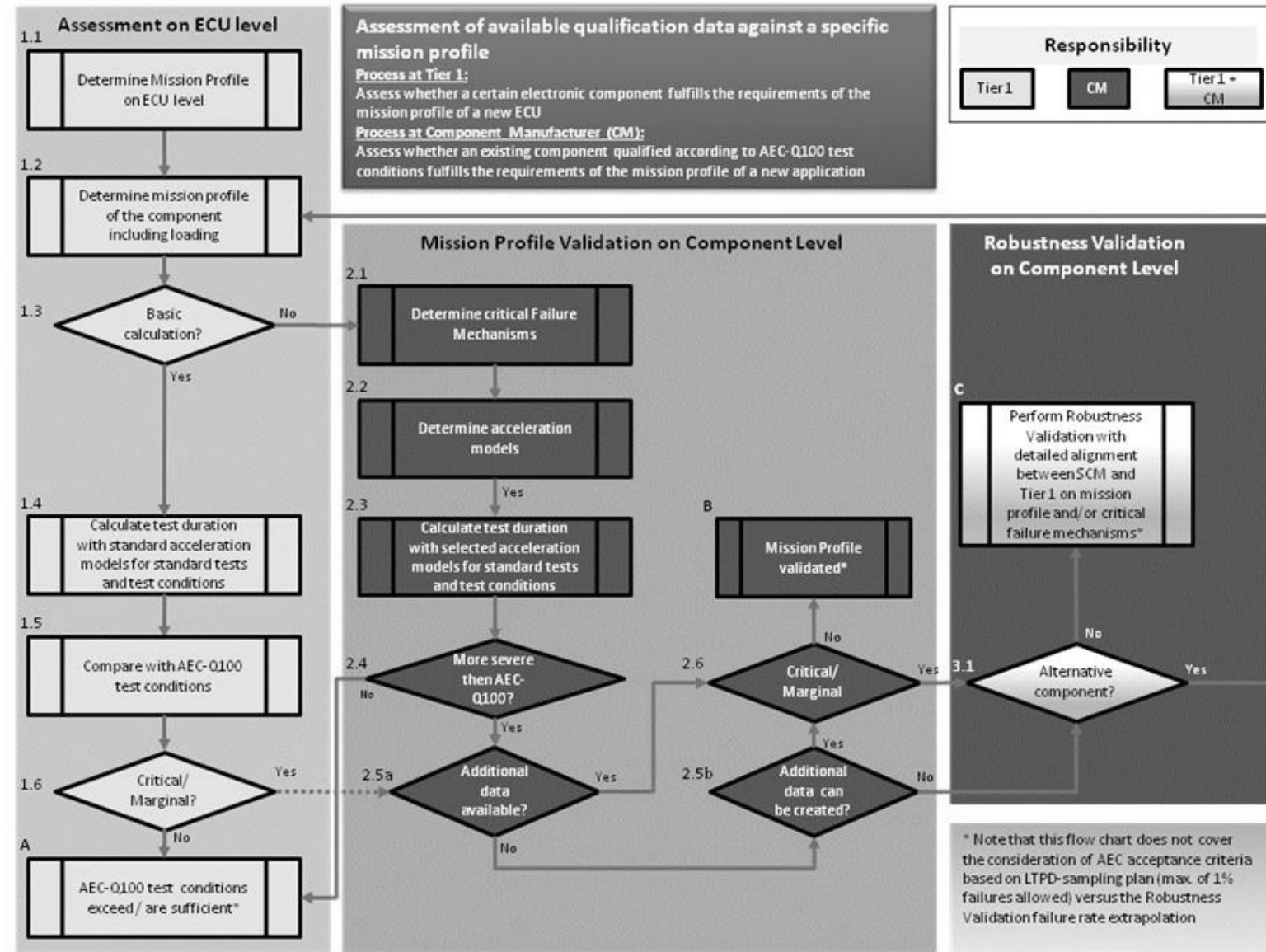


Figure A7.2: Flow Chart 2 – Assessment of Existing, Qualified Component

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**Table A7.1: Basic Calculations for AEC-Q100 Stress Test Conditions and Durations**

<u>Loading</u>	<u>Mission Profile Input</u>	<u>Stress Test</u>	<u>Stress Conditions</u>	<u>Acceleration Model</u> <u>(all temperatures in K, not in °C)</u>	<u>Model Parameters</u>	<u>Calculated Test Duration</u>	<u>Q100 Test Duration</u>
<b>Operation</b>	<p><math>t_u = 12,000</math> hr (average operating use time over 15 yr)</p> <p><math>T_u = 87^\circ\text{C}</math> (average junction temperature in use environment)</p>	High Temperature Operating Life (HTOL)	$T_t = 125^\circ\text{C}$ (junction temperature in test environment)	<p>Arrhenius</p> $A_f = \exp\left[\frac{E_a}{k_B} \cdot \left(\frac{1}{T_u} - \frac{1}{T_t}\right)\right]$ <p>Also applicable for High Temperature Storage Life (HTSL) and NVM Endurance, Data Retention Bake, &amp; Operational Life (EDR)</p>	<p><math>E_a = 0.7</math> eV (activation energy; 0.7 eV is a typical value, actual values depend on failure mechanism and range from -0.2 to 1.4 eV)</p> <p><math>k_B = 8.61733 \times 10^{-5}</math> eV/K (Boltzmann's Constant)</p>	<p><math>t_t = 1393</math> hr (test time)</p> $t_t = \frac{t_u}{A_f}$	1000 hr
<b>Thermo-mechanical</b>	<p><math>n_u = 54,750</math> cls (number of engine on/off cycles over 15 yr of use)</p> <p><math>\Delta T_u = 76^\circ\text{C}</math> (average thermal cycle temperature change in use environment)</p>	Temperature Cycling (TC)	<p><math>\Delta T_t = 205^\circ\text{C}</math> (thermal cycle temperature change in test environment: <math>-55^\circ\text{C}</math> to <math>+150^\circ\text{C}</math>)</p>	<p>Coffin Manson</p> $A_f = \left(\frac{\Delta T_t}{\Delta T_u}\right)^m$ <p>Also applicable for Power Temperature Cycle (PTC)</p>	<p><math>m = 4</math> (Coffin Manson exponent; 4 is to be used for cracks in hard metal alloys, actual values depend on failure mechanisms and range from 1 for ductile to 9 for brittle materials)</p>	<p><math>n_t = 1034</math> cls (number of cycles in test)</p> $n_t = \frac{n_u}{A_f}$	1000 cls
<b>Humidity (Option 1)</b>	<p><math>t_u = 131,400</math> hr (average on/off time over 15 yr of use)</p> <p><math>RH_u = 74\%</math> (average relative humidity in use environment)</p> <p><math>T_u = 32^\circ\text{C}</math> (average temperature in use environment: 9% @ <math>87^\circ\text{C}</math> - time on and 91% @ <math>27^\circ\text{C}</math> - time off)</p>	Temperature Humidity Bias (THB)	<p><math>RH_t = 85\%</math> (relative humidity in test environment)</p> <p><math>T_t = 85^\circ\text{C}</math> (ambient temperature in test environment)</p>	<p>Hallberg-Peck</p> $A_f = \left(\frac{RH_t}{RH_u}\right)^p \cdot \exp\left[\frac{E_a}{k_B} \cdot \left(\frac{1}{T_u} - \frac{1}{T_t}\right)\right]$ <p>Also applicable for Highly Accelerated Steam Test (HAST) and Unbiased Humidity Steam Test (UHST). See Notes.</p>	<p><math>p = 3</math> (Peck exponent, 3 is to be used for bond pad corrosion)</p> <p><math>E_a = 0.8</math> eV (activation energy; 0.8 eV is to be used for bond pad corrosion)</p> <p><math>k_B = 8.61733 \times 10^{-5}</math> eV/K (Boltzmann's Constant)</p>	<p><math>T_t = 960</math> hr</p> $t_t = \frac{t_u}{A_f}$	1000 hr

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**Table A7.1: Basic Calculations for AEC-Q100 Stress Test Conditions and Durations (continued)**

<u>Loading</u>	<u>Mission Profile Input</u>	<u>Stress Test</u>	<u>Stress Conditions</u>	<u>Acceleration Model</u> (all temperatures in K, not in °C)	<u>Model Parameters</u>	<u>Calculated Test Duration</u>	<u>Q100 Test Duration</u>
<b>Humidity (Option 2)</b>	<p><math>t_u = 131,400</math> hr (average on/off time over 15 yr of use)</p> <p><math>RH_u = 74\%</math> (average relative humidity in use environment)</p> <p><math>T_u = 32^\circ\text{C}</math> (average temperature in use environment: 9% @ 87°C - time on and 91% @ 27°C - time off)</p>	Highly Accelerated Steam Test (HAST)	<p><math>RH_t = 85\%</math> (relative humidity in test environment)</p> <p><math>T_t = 130^\circ\text{C}</math> (ambient temperature in test environment)</p>	<p>Hallberg-Peck</p> $A_f = \left( \frac{RH_t}{RH_u} \right)^p \cdot \exp \left[ \frac{E_a}{k_B} \cdot \left( \frac{1}{T_u} - \frac{1}{T_t} \right) \right]$ <p>Also applicable for Temperature Humidity Bias (THB) and Unbiased Humidity Steam Test (UHST). See Notes.</p>	<p><math>p = 3</math> (Peck exponent, 3 is to be used for bond pad corrosion)</p> <p><math>E_a = 0.8</math> eV (activation energy; 0.8 eV is to be used for bond pad corrosion)</p> <p><math>k_B = 8.61733 \times 10^{-5}</math> eV/K (Boltzmann's Constant)</p>	<p><math>T_t = 53</math> hr</p> $t_t = \frac{t_u}{A_f}$	96 hr

Notes:

- Autoclave (121°C/100%RH) is a highly accelerated test using a saturated moisture condition that will tend to uncover failure mechanisms not seen in normal use conditions. For this reason, autoclave is not a test whose test conditions can be derived through models and assumptions. The current test conditions were selected decades ago and the test has been used as part of a standard qualification ever since.
- Most Pressure Pot testing is performed with an Air Pressure Pot. Air purging is done at 100°C boiling water, and with both steam and liquid escaping from the vent. The chamber walls are not independently heated at all. Control of the chamber wall temperature; air purging procedure, during ramp-up; ramp-down temperature and pressure and overall temperature and pressure are key. In addition, when the test is ended the heater is turned off and the vent is opened. It takes about 3 minutes to fully vent the pot. A significant concern is that venting before the pot chamber drops to 100°C, can cause a pressure differential from the >100°C residual hot device and cause any water trapped in device void to create a pop-corning type of delamination.

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**Revision History**

<u>Rev #</u>	<u>Date of change</u>	<u>Brief summary listing affected sections</u>
-	June 9, 1994	Initial Release.
A	May 19, 1995	Added copyright statement. Revised sections 2.3, 2.4.1, 2.4.4, 2.4.5, 2.8, 3.2 and 4.2, Tables 2, 3, 4 and Appendix 1, 2. Added Appendix 3.
B	Sept. 6, 1996	Revised sections 1.1, 1.2.3, 2.3, 3.1, and 3.2.1, Tables 2, 3, and 4, and Appendix 2.
C	Oct. 8, 1998	Revised sections 1.1, 1.1.3, 1.2.2, 2.2, 2.3, 2.4.2, 2.4.5, 2.6, 3.1, 3.2.1, 3.2.3, 2.3.4, 4.1, and 4.2, Tables 3 and 4, Appendix 2, and Appendix 3. Added section 1.1.1, Figures 1, 2, and 3, and Test Methods Q100-008 and -009. Deleted sections 2.7 and 2.8.
D	Aug. 25, 2000	Revised sections 1.1 and 2.3, Figures 2, 3, and 4, Tables 2, 3, and 4, Appendix 1, and Appendix 2. Added section 2.3.2, Test Methods Q100-010 and -011, and Figure 1.
E	Jan. 31, 2001	Revised Figure 4.
F	July 18, 2003	Complete Revision.
G	May 14, 2007	Complete Revision. Revised document title to reflect that the stress test qualification requirements are failure mechanism based. Revised sections 1, 1.1, 1.2.1, 1.2.2, 1.2.3, 2.3.1, 2.4.4, 2.5, 3.2, 3.2.3, 4.2, and 4.3, Figure 2, Tables 2 and 3, Appendix 2, Appendix 4A, and Appendix 4B. Added sections 2.1.1, 3.1.1, Table 2 and 3 entries (test #D4, D5, E10, and E11), Appendix 6, and Test Method Q100-012. Deleted Table 2A.
H	<u>Sept. 11, 2014</u>	<u>Complete Revision. Revised sections 1.2.1, 1.3.1, 1.3.3, 2.2, 2.3.1, 2.3.3, 2.4.1, 2.4.5, 2.5, and 3.2.3, Figure 2, Tables 1 and 2, Appendix 1, Appendix 4A, Appendix 4B, and Revision History. Added Revision Summary, sections 1.2.4, 1.3.2, 1.3.4, 1.3.5, and 3.3, Table 2 and 3 entry (test #E12), Table 2 Legend (Note L), Tables A1.1 and A1.2, Appendix 7, Figures A7.1 and A7.2, and Table A7.1. Deleted section 3.1.1, Table 2 and 3 entries (test #E2 and E8).</u>